

STIC Search Report

STIC Database Tracking Number 214995

TO: Michael Bernshteyn Location: Remsen 10a34

Art Unit: 1713 February 8, 2007

Phone: 571-272-2411

Serial Number: 10 / 523085

From: Jan Delaval

Location: EIC 1700

Remsen 4a30

Phone: 571-272-2504 jan.delaval@uspto.gov

Search Notes	
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SEARCH REQUEST FORM

Scientific and Technical Information Center

Access DB# 214995

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Requester's Full Name: Mich. Art Unit: 17/2 Phone Mail Box and Bldg/Room Location	AEL BERNSHIT Number 30 <u>272-3</u> ion: Lem. 10 A 34 Re	EVNExaminer #: 8/5/5 Date: 0/07/07 24// Serial Number: 10/523,085 esults Format Preferred (circle): PAPER DISK E-MAIL
If more than one search is sub	omitted, please priori	tize searches in order of need. ***********************************
Please provide a detailed statement of t Include the elected species or structures	he search topic, and describ s, keywords, synonyms, acr ns that may have a special	oe as specifically as possible the subject matter to be searched. onyms, and registry numbers, and combine with the concept or meaning. Give examples or relevant citations, authors, etc. if
Title of Invention: Solid p	olymer sloot	nolube
Inventors (please provide full names)	Hiron Mu	rolyte eamoto, Taxeshi Nitani
Earliest Priority Filing Date:	7/23/2002	
For Sequence Searches Only Please inc	, ,	n (parent, child, divisional, or issued patent numbers) along with the
appropriate serial number.		
of claims 1,2,	16 and depen	ner according with limitations adable claims 3-15 and 17-25
•		
		Thank you
		M. Eernskeyn
		SCIENTITIC REFERENCE BR Sci 2 rech Inf - Cntr
		FEB 7 RECU
		Pat. & T.M. Office
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		•
*******	******	*********
TAFF USE ONLY	Type of Search	Vendors and cost where applicable
earcher:	NA Sequence (#)	STN
earcher Phone #: 27504	AA Sequence (#)	Dialog
earcher Location:	Structure (#)	Questel/Orbit
ate Searcher Picked Up: 218107	Bibliographic	Dr.Link
ate Completed: 7(8(07	Litigation	Lexis/Nexis
earcher Prep & Review Time:	Fulltext	Sequence Systems
lerical Prep Time: 40	Patent Family	WWW/Internet

=> fil reg FILE 'REGISTRY' ENTERED AT 08:21:14 ON 08 FEB 2007 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2007 American Chemical Society (ACS)

Property values tagged with IC are from the ZIC/VINITI data file provided by InfoChem.

STRUCTURE FILE UPDATES: 7 FEB 2007 HIGHEST RN 919834-45-0 DICTIONARY FILE UPDATES: 7 FEB 2007 HIGHEST RN 919834-45-0

New CAS Information Use Policies, enter HELP USAGETERMS for details.

TSCA INFORMATION NOW CURRENT THROUGH June 30, 2006

Please note that search-term pricing does apply when conducting SmartSELECT searches.

REGISTRY includes numerically searchable data for experimental and predicted properties as well as tags indicating availability of experimental property data in the original document. For information on property searching in REGISTRY, refer to:

http://www.cas.org/ONLINE/UG/regprops.html

```
=> d sta que 134
         170646 SEA FILE=REGISTRY ABB=ON PLU=ON C2H4O OR C3H6O OR C4H8O
L10
L11
         112703 SEA FILE=REGISTRY ABB=ON PLU=ON (75-21-8 OR 25322-68-3 OR
                107-21-1 OR 75-56-9 OR 25322-69-4 OR 57-55-6 OR 504-63-2 OR
                201732-70-9 OR 170678-59-8 OR 26264-14-2 OR 106-88-7 OR
                109-99-9 OR 25190-06-1)/CRN
L12
          22014 SEA FILE=REGISTRY ABB=ON PLU=ON (2163-42-0 OR 110-63-4 OR
                107-88-0 OR 25265-75-2 OR.159806-32-3 OR 168011-04-9 OR
                799775-81-8)/CRN
L13
             76 SEA FILE=REGISTRY ABB=ON PLU=ON (1758-32-3 OR 3266-23-7 OR
                1758-33-4 OR 63864-69-7 OR 21490-63-1)/CRN
L14
         161417 SEA FILE=REGISTRY ABB=ON PLU=ON (L10 OR L11 OR L12 OR L13)
                AND PMS/CI AND NR>=1
L15
                STR
        5
        0
     2
        3
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NODE ATTRIBUTES:
DEFAULT MLEVEL IS ATOM
DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES: RING(S) ARE ISOLATED OR EMBEDDED NUMBER OF NODES IS 5

STEREO ATTRIBUTES: NONE

L17 78102 SEA FILE=REGISTRY SUB=L14 SSS FUL L15

L18 STR

c = c - cy1 2 3

NODE ATTRIBUTES:

DEFAULT MLEVEL IS ATOM

DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED

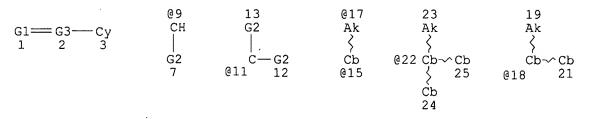
NUMBER OF NODES IS 3

STEREO ATTRIBUTES: NONE

L20 14509 SEA FILE=REGISTRY SUB=L17 SSS FUL L18

L21

STR



@27 C | G2 26

VAR G1=CH2/9/11 VAR G2=AK/CB/17/15/18/22 VAR G3=CH/27 NODE ATTRIBUTES: DEFAULT MLEVEL IS ATOM DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES:

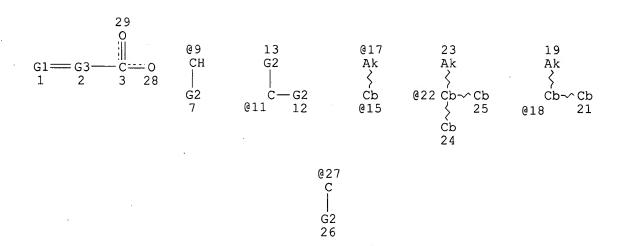
RING(S) ARE ISOLATED OR EMBEDDED

NUMBER OF NODES IS 19

STEREO ATTRIBUTES: NONE

L23 10616 SEA FILE=REGISTRY SUB=L20 CSS FUL L21

L24 STR

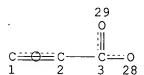


VAR G1=CH2/9/11 VAR G2=AK/CB/17/15/18/22 VAR G3=CH/27 NODE ATTRIBUTES: CONNECT IS M1 RC AT 28 DEFAULT MLEVEL IS ATOM DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES: RING(S) ARE ISOLATED OR EMBEDDED NUMBER OF NODES IS 21

STEREO ATTRIBUTES: NONE

L26 9174 SEA FILE=REGISTRY SUB=L23 CSS FUL L24 STR



NODE ATTRIBUTES:
CONNECT IS M1 RC AT 28
DEFAULT MLEVEL IS ATOM
DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES: RING(S) ARE ISOLATED OR EMBEDDED NUMBER OF NODES IS 5

STEREO ATTRIBUTES: NONE

L29 2370 SEA FILE=REGISTRY SUB=L23 SSS FUL L27 STR

C=X=C-C=0-G1-0 1 2 3 4 6 7

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VAR G1=AK/ID
NODE ATTRIBUTES:
CONNECT IS M1
               RC AT
                        1
CONNECT IS M1
               RC AT
                        2
CONNECT IS M1
               RC AT
DEFAULT MLEVEL IS ATOM
DEFAULT ECLEVEL IS LIMITED
GRAPH ATTRIBUTES:
RING(S) ARE ISOLATED OR EMBEDDED
NUMBER OF NODES IS
STEREO ATTRIBUTES: NONE
L32
          10157 SEA FILE=REGISTRY ABB=ON PLU=ON (L26 OR L29)
L34
           4847 SEA FILE=REGISTRY SUB=L32 CSS FUL L31
100.0% PROCESSED
                    8893 ITERATIONS
                                                             4847 ANSWERS
SEARCH TIME: 00.00.01
=> d his
     (FILE 'HOME' ENTERED AT 06:29:58 ON 08 FEB 2007)
                SET COST OFF
     FILE 'HCAPLUS' ENTERED AT 06:30:22 ON 08 FEB 2007
L1
              1 S US20050256256/PN OR (US2005-532085# OR WO2003-JP9328 OR JP200
                E MURAMOTO/AU
                E MURAMOTO H/AU
L2
             77 S E3,E17
                E MURAMOTO NAME/AU
                E HIROO/AU
                E MIITANI/AU
                E NIITANI/AU
L3
             10 S E31
                E NITANI/AU
L4
              1 S E25
                E TAKESHI/AU
L5
              4 S E3
                E TAKESHI N/AU
L6
              4 S E9
T.7
           3937 S (NIPPON?(L)SODA?)/PA,CS
                SEL RN L1
     FILE 'REGISTRY' ENTERED AT 06:33:22 ON 08 FEB 2007
^{18}
              8 S E1-E8
L9
              5 S L8 AND 2/NC AND PMS/CI
L10
         170646 S C2H4O OR C3H6O OR C4H8O
         112703 S (75-21-8 OR 25322-68-3 OR 107-21-1 OR 75-56-9 OR 25322-69-4 O
L11
L12
          22014 S (2163-42-0 OR 110-63-4 OR 107-88-0 OR 25265-75-2 OR 159806-32
L13
             76 S (1758-32-3 OR 3266-23-7 OR 1758-33-4 OR 63864-69-7 OR 21490-6
         161417 S L10-L13 AND PMS/CI AND NR>=1
L14
L15
                STR
L16
             50 S L15 SAM SUB=L14
L17
          78102 S L15 FUL SUB=L14
L18
                STR
L19
             50 S L18 SAM SUB=L17
L20
          14509 S L18 FUL SUB=L17
                SAV TEMP L20 BERNSH523/A
```

```
L21
                STR L18
L22
             50 S L21 CSS SAM SUB=L20
L23
          10616 S L21 CSS FUL SUB=L20
                 SAV TEMP L23 BERNSH523A/A
L24
                STR L21
L25
             50 S L24 CSS SAM SUB=L23
           9174 S L24 CSS FUL SUB=L23
L26
                 SAV TEMP L26 BERNSH523B/A
L27
                STR L24
L28
             50 S L27 SAM SUB=L23
L29
           2370 S L27 FUL SUB=L23
                 SAV TEMP L29 BERNSH523C/A
L30
            459 S L23 NOT L26, L29
L31
                STR L15
          10157 S L26, L29
L32
L33
             50 S L31 CSS SAM SUB=L32
L34
           4847 S L31 CSS FUL SUB=L32
                SAV TEMP L34 BERNSH523D/A
L35
           3195 S L34 NOT L11-L13
L36
            106 S L35 AND 2/NC
             10 S L36 AND ("(C8H8.(C2H4O)NC6H10O3)X" OR "(C8H8.(C3H6O)NC28H30N4
L37
L38
              4 S L36 AND (FE OR ZR)/ELS
L39
             11 S L36 AND ("(C8H8.(C3H6O)N(C3H6O)N(C3H6O)NC15H2OO6)X" OR "(C8H8
              4 S L36 AND ("(C8H8.(C3H6O)N(C3H6O)NC24H30O6S4)X" OR "(C8H8.(C3H6
L40
             79 S L36 NOT L37-L40
L41
L42
              7 S L41 AND
                           ("(C7H7N.(C2H4O)NC8H10O3)X" OR "(C9H10.(C2H4O)N(C2H4
L43
              1 S L41 AND C18H26O6
L44
              3 S L41 AND ("(C8H8.(C2H4O)N(C2H4O)NC21H2OO4)X" OR "(C8H8.(C2H4O)
L45
              7 S L41 AND ("(C8H8.(C2H4O)NC11H2OO3)X" OR "(C8H8(C2H4O)NC6H6O3)X
L46
             61 S L41 NOT L42-L45
              4 S L46 AND ("(C8H8.(C4H8O)NC8H10O3)X" OR "(C8H8.(C2H4O)NC6H6O3)X
L47
L48
             57 S L46 NOT L47
            370 S L35 AND 3/NC
L49
L50
           1652 S L34 NOT L35
              0 S L50 AND 2/NC
L51
L52
             16 S L50 AND 3/NC
                SEL RN 2 3 10 11 16
L53
             11 S L52 NOT E9-E13
L54
             96 S L50 AND 4/NC
             50 S L54 NOT N/ELS
L55
             45 S L55 NOT OC4/ES
L56
L57
             43 S L56 NOT C6H10O2
L58
             42 S L57 NOT "(C8H8.C7H12O3.C7H12O2.(C2H4O)N(C2H4O)NC23H24O4)X"/MF
                SEL RN 6 8-10 13 20 23-25 29 33 37-39 42
L59
             15 S E14-E28
L60
             84 S L48, L9, L53, L59
L61
            171 S L50 AND 5/NC
     FILE 'HCAPLUS' ENTERED AT 08:02:26 ON 08 FEB 2007
L62
            246 S L60
L63
             79 S L62 AND PY<=2002 NOT P/DT
L64
            119 S L62 AND (PD<=20020723 OR PRD<=20020723 OR AD<=20020723) AND P
L65
            198 S L63, L64
L66
             11 S L1-L7 AND L62
                E POLYMER ELECTROLYTE/CT
                E E5+ALL
L67
           4300 S E9
L68
          43505 S E7 4
L69
          13824 S E12+OLD, NT OR E14+OLD, NT
                E E16+ALL
```

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L70
          20528 S E8
                 E E24+ALL
                 E E13+ALL
L71
          17248 S E5, E6
                 E BATTERY/CT
                 E E9+ALL
L72
           8803 S E2+OLD, NT OR E3+OLD, NT OR E4+OLD, NT
                 E BATTERY/CT
L73
          58449 S E4+OLD, NT OR E5+OLD, NT OR E6+OLD, NT OR E7 OR E8+OLD, NT
                 E BATTERIES/CT
                 E E3+ALL
L74
         120592 S E1 OR E2+OLD, NT OR E3+OLD, NT OR E4+OLD, NT OR E5+OLD, NT
L75
               4 S L65 AND L67-L74
L76
               6 S L65 AND ?ELECTROLYT?
L77
               1 S L65 AND (BATTERY OR FUEL CELL OR ENERG?(L)CONVERT?)
                 E IONIC CONDUCT/CT
L78
          19490 S E7+OLD, NT OR E10+OLD, NT OR E11
L79
               2 S L65 AND L78
              18 S L66, L75-L77, L79
L80
                 E ELECRODE/CT
                 E ELECTRODE/CT
                 E E90+ALL
L81
         221163 S E3+NT
L82
              0 S L65 AND L81
L83
              0 S L65 AND ?ELECTROD?
L84
              21 S L64 AND US/PC
L85
              21 S L64 AND US/PRC, AC
L86
              21 S L84, L85
L87
              20 S L86 NOT L80
L88
              1 S L86 AND L80
L89
             18 S L80, L88
     FILE 'REGISTRY' ENTERED AT 08:10:05 ON 08 FEB 2007
     FILE 'HCAPLUS' ENTERED AT 08:10:05 ON 08 FEB 2007
L90
                                       115 TERMS
                 TRA L89 1- RN :
     FILE 'REGISTRY' ENTERED AT 08:10:06 ON 08 FEB 2007
L91
            115 SEA L90
L92
              33 S L91 AND L17
L93
              22 S L92 NOT L60
                 SEL RN 2 6 7 9 10 19 22
L94
             15 S L93 NOT E1-E7
     FILE 'HCAPLUS' ENTERED AT 08:13:47 ON 08 FEB 2007
L95
                 TRA L87 1- RN :
                                       201 TERMS
     FILE 'REGISTRY' ENTERED AT 08:13:48 ON 08 FEB 2007
L96
            201 SEA L95
L97
              42 S L96 AND L17
L98
              39 S L97 NOT L91
                 SEL RN 1 5 6 10 11 15 16 18-21 25 26 31 33-36 39
L99
             20 S L98 NOT E8-E26
L100
              3 S L97 NOT L98
L101
             23 S L99, L100
     FILE 'HCAPLUS' ENTERED AT 08:19:18 ON 08 FEB 2007
L102
              7 S L94 AND L89
L103
             18 S L60 AND L89
L104
             18 S L102, L103
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FILE 'REGISTRY' ENTERED AT 08:21:14 ON 08 FEB 2007

=> fil hcaplus FILE 'HCAPLUS' ENTERED AT 08:21:30 ON 08 FEB 2007 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2007 AMERICAN CHEMICAL SOCIETY (ACS)

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FILE COVERS 1907 - 8 Feb 2007 VOL 146 ISS 7 FILE LAST UPDATED: 7 Feb 2007 (20070207/ED)

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This file contains CAS Registry Numbers for easy and accurate substance identification.

=> d l110 bib abs hitind hitstr retable tot

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L110 ANSWER 1 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
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AN 2006:733246 HCAPLUS

DN 145:168563

- TI Polymers for solid polymer electrolytes with good thermal and physical properties and adhesives
- IN Niitani, Takeshi; Amaike, Masato; Shimada, Mikiya; Kawamura, Kiyoshi

PA Nippon Soda Co., Ltd., Japan

SO PCT Int. Appl., 53 pp. CODEN: PIXXD2

DT Patent

LA Japanese

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PAN.	CNT	Ţ																
	PATENT NO.					KIN	D	DATE			APPL	ICAT:	ION	NO.		D	ATE	
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ΡI	WO	2006	0778	55		A1 20060727			WO 2006-JP300599						20060118			
		W:	ΑE,	AG,	ΑL,	ΑM,	AT,	ΑU,	AZ,	BA,	BB,	BG,	BR,	BW,	BY,	BZ,	CA,	CH,
								DE,										
								ID,										
			ΚZ,	LC,	LK,	LR,	LS,	LT,	LU,	LV,	LY,	MA,	MD,	MG,	MK,	MN,	MW,	MX,
			ΜZ,	NA,	NG,	ΝI,	NO,	ΝZ,	OM,	PG,	PH,	PL,	PT,	RO,	RU,	SC,	SD,	SE,
			SG,	SK,	SL,	SM,	SY,	ТJ,	TM,	TN,	TR,	TT,	TZ,	UA,	UG,	US,	UZ,	VC,
			VN,	YU,	ZA,	ZM,	zw									•	-	•
		RW:	AT,	BE,	BG,	CH,	CY,	CZ,	DE,	DK.	EE.	ES.	FI.	FR.	GB.	GR.	HU.	TE.

IS, IT, LT, LU, LV, MC, NL, PL, PT, RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG, BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM PRAI JP 2005-14195 Α 20050121 Title polymers comprise a block chain A composed of a random copolymer containing a repeating units [CR1R2CR3CO2(CR4aHCHR4bO)mR5] and CR6R7CR8R9 and a block chain B containing a repeating unit CR10R11CR12R13 in the BAB order, wherein R1, R2, R3, R6, R8, R10, R11, R12 = H or a C1-10 hydrocarbon; R4a, R4b = H or methyl; R5 = H or hydrocarbon; R7 = H, C1-10 hydrocarbon, or OH; R9 + OH, carboxy, or epoxy; R13 = aryl or heteroaryl group; and m =1-100 integer. Solid polymer electrolytes composition comprise a crosslinked polymer obtained by reacting the polymer with a crosslinking agent and an electrolyte salt. Thus, 30.0 g Blemmer PME 400 and 3.3 g 2-hydroxyethyl methacrylate were polymerized in the presence of dichlorotris(triphenylphosphi ne)ruthenium, dibutylamine, and 2,2-dichloroacetophenone at 80° for 22 h to give a copolymer with Mn 129,000 and polydispersity 1.37, 20.0 g of which was mixed with 8.6 g styrene and polymerized in the presence of chloropentamethylcyclopentadienylbis(triphenylphopshine)ruthenium and dibutylamine at 100° for 42 h to give a triblock copolymer, 2 g of which was mixed with 0.15 g tolylene-2,4-diisocyanate and 0.15 g lithium hexafluorophosphate in 18 g a solvent mixture, cast into a film, and heated at 60° for 5 h and 100° for 10 h to give a solid polymer electrolyte, showing ionic conductivity 9.4 + 10-6 S/cm at 20° and 9.7 + 10-5 S/cm at 60° . 38-3 (Plastics Fabrication and Uses) Section cross-reference(s): 52 IT 343978-26-7P 901450-79-1P 901450-80-4P RL: IMF (Industrial manufacture); RCT (Reactant); PREP (Preparation); RACT (Reactant or reagent) (Blemmer PME 1000, intermediate; polymers for solid polymer electrolytes with good thermal and phys. properties and adhesives) ΙT 901450-79-1P 901450-80-4P RL: IMF (Industrial manufacture); RCT (Reactant); PREP (Preparation); RACT (Reactant or reagent) (Blemmer PME 1000, intermediate; polymers for solid polymer electrolytes with good thermal and phys. properties and adhesives) RN 901450-79-1 HCAPLUS CN 2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with ethenylbenzene and α -(2-methyl-1-oxo-2-propenyl)- ω methoxypoly(oxy-1,2-ethanediyl), graft, triblock (9CI) (CA INDEX NAME) CM 1 CRN 26915-72-0 CMF (C2 H4 O)n C5 H8 O2 CCI **PMS**

$$\begin{array}{c|c}
\text{H2C} & O \\
\text{Me} & C & C
\end{array}$$

$$\begin{array}{c|c}
\text{O-CH}_2 - \text{CH}_2
\end{array}$$

$$\begin{array}{c|c}
\text{OMe}$$

CM 2 ·

CRN 868-77-9 CMF C6 H10 O3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 901450-80-4 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with ethenylbenzene and oxirane, graft, triblock (9CI) (CA INDEX NAME)

CM 1

CRN 868-77-9 CMF C6 H10 O3

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

CM 3

CRN 75-21-8 CMF C2 H4 O



RETABLE

Referenced Author	Year VOL PG		Referenced		
(RAU)	(RPY) (RVL) (RPG)		File		
Nippon Soda Co Ltd	2004	EP 1553117 A1	HCAPLUS		
Nippon Soda Co Ltd		WO 2004009663 A1	HCAPLUS		
Nippon Soda Co Ltd		JP 2004107641 A	HCAPLUS		

y.,

CCI PMS

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12004
                                         JP 2004213940 A
Nippon Soda Co Ltd
                                                               IHCAPLUS
                      12004 |
Nippon Soda Co Ltd
                                          |US 2005256256 A1
                                                               | HCAPLUS
                                   - 1
Nippon Soda Co Ltd
                      12005 |
                                          |WO 2005027144 A1
                                                               IHCAPLUS
                                   -1
Nippon Soda Co Ltd
                       12005 |
                                          JP 2005089510 A
                                                               IHCAPLUS
                                   1
L110 ANSWER 2 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
     2006:632998 HCAPLUS
AN
     145:112030
DN
TI
     Solid polymer electrolyte compositions and solid polymer electrolytes
     having excellent thermal characteristics, mechanical strength and ion
     conductivity for electrochemical devices
IN
     Shintani, Takeshi
PΑ
     Nippon Soda Co., Ltd., Japan
SO
     Jpn. Kokai Tokkyo Koho, 34 pp.
     CODEN: JKXXAF
DT
     Patent
LA
     Japanese
FAN.CNT 1
     PATENT NO.
                        KIND
                                DATE
                                          APPLICATION NO.
                                                                  DATE
                                                                   _____
     JP 2006172822
                        Α
                                20060629
                                           JP 2004-361520
                                                                   20041214
PRAI JP 2004-361520
                                20041214
     Solid polymer electrolyte compns. contain copolymers having repeating unit
     containing cyclic functional group having ring-opening ability and repeating
     unit having ion conductive part and electrolytic salts. The cyclic
     functional group having ring-opening ability is groups having cycloalkane
     aryl structure, cycloalkadiene aryl structure, cyclobutene aryl structure
     or cyclobutadiene aryl structure. Solid polymer electrolytes are obtained
     from the solid polymer electrolyte compns. by ring-opening reaction.
     copolymers have number-average mol. weight of 5000-1,000,000 and are
     coupling-crosslinked to obtain crosslinked polymers. The solid polymer
     electrolyte compns. are used as electrochem. device materials such as
     battery, capacitor, sensor, photoelec. conversion device, etc.
CC
     72-11 (Electrochemistry)
     Section cross-reference(s): 38, 52, 76, 79, 80
     92361-49-4P 99717-87-0P 112119-04-7P
IT
     RL: SPN (Synthetic preparation); TEM (Technical or engineered material
     use); PREP (Preparation); USES (Uses)
        (solid polymer electrolyte compns. and solid polymer electrolytes
        having excellent thermal characteristics, mech. strength and ion
conductivity
        for electrochem. devices)
TΤ
     112119-04-7P
     RL: SPN (Synthetic preparation); TEM (Technical or engineered material
     use); PREP (Preparation); USES (Uses)
        (solid polymer electrolyte compns. and solid polymer electrolytes
        having excellent thermal characteristics, mech. strength and ion
conductivity
        for electrochem. devices)
     112119-04-7 HCAPLUS
RN
     Poly(oxy-1,2-ethanediyl), \alpha-(2-methyl-1-oxo-2-propenyl)-\omega-
CN
     methoxy-, polymer with ethenylbenzene, block (9CI) (CA INDEX NAME)
     CM
     CRN
          26915-72-0
     CMF
          (C2 H4 O)n C5 H8 O2
```

$$H_2C$$
 O H_2C H_2C

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

CM

```
L110 ANSWER 3 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
     2006:317430 HCAPLUS
     144:353731
DN
ΤI
     Polymer electrolyte batteries with electrolytes containing block
     copolymers
IN
     Shimada, Mikiya; Amaike, Masato; Shintani, Takeshi; Kawamura, Kiyoshi
PA
     Nippon Soda Co., Ltd., Japan
SO
     Jpn. Kokai Tokkyo Koho, 40 pp.
     CODEN: JKXXAF
DT
     Patent
LA
     Japanese
FAN.CNT 1
     PATENT NO.
                         KIND
                                 DATE
                                              APPLICATION NO.
                                                                      DATE
                          ____
                                              -----
ΡI
     JP 2006092792
                                 20060406
                          Α
                                              JP 2004-273632
                                                                      20040921
PRAI JP 2004-273632
                                 20040921
     The title batteries are equipped with polymer electrolytes containing
     electrolyte salts and provide voltage resistance \geq 4.2~\text{V} and conductivity
     at 23° \geq 1 + 10-5 S/cm. The polymer electrolytes
     consist of repeating units CR1R2CR3[CO2(CHR4bCHR4aO)mR5] (I; R1-R3 = H,
     C1-10 hydrocarbyl; R1 and R3 may be bonded to form a ring; R4a and R4b =
     H, Me; R5 = H, hydrocarbyl, acyl, silyl; m = 2-100), CR6R7CR8R9 (II; R6-R8
     = H, C1-10 hydrocarbyl; R9 = (substituted) aryl), and CR10R11CR12R13 (III;
     R10-R12 = H, C1-10 hydrocarbyl; R13 = (substituted) aryl, heteroaryl) at mol ratio I/(II + III) 1/30 to 30/1. The polymer electrolytes are
     suitable for 5 V-class secondary Li batteries.
     52-2 (Electrochemical, Radiational, and Thermal Energy Technology)
CC
     Section cross-reference(s): 38
IT
     697284-07-4DP, lithium complexes
     RL: DEV (Device component use); IMF (Industrial manufacture); PREP
     (Preparation); USES (Uses)
        (comb block-containing; polymer electrolyte batteries with electrolytes
        containing block copolymers)
IT
     697284-07-4DP, lithium complexes
     RL: DEV (Device component use); IMF (Industrial manufacture); PREP
     (Preparation); USES (Uses)
        (comb block-containing; polymer electrolyte batteries with electrolytes
        containing block copolymers)
RN
     697284-07-4 HCAPLUS
CN
     Poly(oxy-1,2-ethanediyl), \alpha-(2-methyl-1-oxo-2-propenyl)-\omega-
     methoxy-, polymer with ethenylbenzene, triblock (9CI) (CA INDEX NAME)
```

```
CRN
             26915-72-0
       CMF
              (C2 H4 O)n C5 H8 O2
       CCI
             PMS
     C 0
  H<sub>2</sub>C
                  O-CH2-CH2
       CM
              2
       CRN 100-42-5
       CMF C8 H8
H_2C = CH - Ph
L110 ANSWER 4 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
       2006:149532 HCAPLUS
       144:233946
DN
      Multibranched polymers with narrow molecular weight distribution, their
      manufacture and uses
IN
      Niitani, Takeshi; Kawamura, Kiyoshi; Shirai, Akihiro
PA
      Nippon Soda Co., Ltd., Japan
       PCT Int. Appl., 128 pp.
SO
       CODEN: PIXXD2
DT
       Patent
LA
       Japanese
FAN.CNT 1
       PATENT NO.
                                  KIND
                                            DATE
                                                            APPLICATION NO.
                                                                                            DATE
                                  ____
                                            -----
                                                            -----
PΙ
      WO 2006016665
                                   A1
                                            20060216
                                                            WO 2005-JP14788
                                                                                            20050811
            W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KM, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NG, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SM, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU,
                  ZA, ZM, ZW
            RW: AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LT, LU, LV, MC, NL, PL, PT, RO, SE, SI, SK, TR, BF, BJ,
                 CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG, BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM
PRAI JP 2004-235855
                                   Α
                                            20040813
      JP 2004-368908
                                   Α
                                            20041221
       JP 2005-24232
                                   A
                                            20050131
AB
      The invention relates to multibranched polymers represented by AR1aR2b-a
       (A = organic groups with b valency; R1 = XnYQ where X = group 14-16
      element-containing bridge; Y = groups can bear active halogen atoms; Q =
      polymer chains derived from unsatd. compound polymerization; n = 0 or \geq 1; R2
       = organic groups inert to polymerization; a = number of R1 chains introduced
on A; b =
      valency of A). The polymers can be prepared by using a core compound which
```

```
has multiple polymerization initiation sites and the living radical
polymerization of
     unsatd. monomers. Thus, reacting 1,1,2,2-tetrakis(4-hydroxyphenyl)ethane
     with 2-bromoisobutyric acid gave a multiple-site initiator on which Me
     methacrylate was polymerized to give a multibranched polymer.
     37-3 (Plastics Manufacture and Processing)
CC
     Section cross-reference(s): 52
IT
     876347-68-1P 876347-68-1P 876368-09-1P
     876368-09-1P
     RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical or
     engineered material use); PREP (Preparation); USES (Uses)
        (multibranched polymers with narrow mol. weight distribution, their
manufacture
        and use in polymer electrolytes or adhesives)
     7439-93-2DP, Lithium, macromer polymer complexes
ΙT
                                                         9003-53-6P, Polystyrene
     9011-14-7P, Methyl methacrylate polymer 87105-87-1P, Polyethylene glycol
     monomethacrylate methyl ether homopolymer
                                                 186454-05-7P, tert-Butvl
     acrylate-methyl acrylate copolymer
                                         697291-45-5DP, lithium complex,
     perchlorate-containing 731852-85-ODP, Blemmer PME 400-styrene
     diblock copolymer, lithium complex, perchlorate-containing
     RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical or
     engineered material use); PREP (Preparation); USES (Uses)
        (multibranched; multibranched polymers with narrow mol. weight
        distribution, their manufacture and use in polymer electrolytes or
        adhesives)
IT
     343978-14-3P
                    343978-26-7P
     RL: IMF (Industrial manufacture); RCT (Reactant); PREP (Preparation); RACT
     (Reactant or reagent)
        (multibranched; multibranched polymers with narrow mol. weight
        distribution, their manufacture and use in polymer electrolytes or
        adhesives)
     876347-68-1P 876368-09-1P
ΙT
     RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical or
     engineered material use); PREP (Preparation); USES (Uses)
        (multibranched polymers with narrow mol. weight distribution, their
manufacture
        and use in polymer electrolytes or adhesives)
     876347-68-1 HCAPLUS
RN
CN
     2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with
     ethenylbenzene and oxirane, methyl ether, block, graft (9CI) (CA INDEX
     NAME)
     CM
          1
     CRN
         67-56-1
     CMF C H4 O
нзс-он
     CM
          2
     CRN
          876347-67-0
          (C8 H8 . C6 H10 O3 . C2 H4 O) \times
     CMF
     CCI
          PMS
          CM
               3
```

CRN 868-77-9 CMF C6 H10 O3

CM 4

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

CM 5

CRN 75-21-8 CMF C2 H4 O



RN 876368-09-1 HCAPLUS CN 2-Propenoic acid. 2-m

2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with ethenylbenzene and $\alpha\text{-}(2\text{-methyl-}1\text{-}oxo\text{-}2\text{-propenyl})\text{-}\omega\text{-}$ methoxypoly(oxy-1,2-ethanediyl), block, graft (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$\begin{array}{c|c} ^{\text{H}_2\text{C}} & \text{O} \\ \parallel & \parallel \\ \text{Me-C-C-C-} & \text{O-CH}_2\text{--CH}_2 \\ \hline \end{array} \right. \\ \text{OMe}$$

CM 2

CRN 868-77-9 CMF C6 H10 O3

$$^{\rm H_2C}$$
 O $^{\rm H_2H_2}$ Me $^{\rm C-C-O-CH_2-CH_2-OH}$

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

T31852-85-ODP, Blemmer PME 400-styrene diblock copolymer, lithium complex, perchlorate-containing RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (multibranched; multibranched polymers with narrow mol. weight distribution, their manufacture and use in polymer electrolytes or adhesives)

RN 731852-85-0 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω -methoxy-, polymer with ethenylbenzene, diblock (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$H_2C$$
 O H_2C CH_2 CH_2 OMe

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

IT 343978-14-3P

RL: IMF (Industrial manufacture); RCT (Reactant); PREP (Preparation); RACT (Reactant or reagent)

(multibranched; multibranched polymers with narrow mol. weight distribution, their manufacture and use in polymer electrolytes or adhesives)

RN 343978-14-3 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with oxirane, methyl ether, graft (9CI) (CA INDEX NAME)

CM 1

CRN 67-56-1 CMF C H4 O нзс-он

CM 2

CRN 229647-70-5

CMF (C6 H10 O3 . C2 H4 O)x

CCI PMS

CM 3

CRN 868-77-9 CMF C6 H10 O3

CM 4

CRN 75-21-8 CMF C2 H4 O



PRAI JP 2004-56493

(RAU)	(RPY)	(RVL) (RPG)	(RWK)	Referenced File
Nippon Soda Co Ltd Nippon Soda Co Ltd Nippon Soda Co Ltd Nippon Soda Co Ltd Sekisui Chemical Co Ltd Sekisui Chemical Co Ltd Sekisui Chemical Co Ltd	2002 2004 2004 2004 1992 1992		JP 200220479 A JP 2004107641 A JP 2004189664 A WO 20049663 A1 JP 04-363306 A EP 464408 A1	HCAPLUS HCAPLUS HCAPLUS HCAPLUS HCAPLUS HCAPLUS
L110 ANSWER 5 OF 40 HC AN 2005:1102873 HCAP DN 143:389768 TI Solid polymer elec IN Kawamura, Kiyoshi; PA Nippon Soda Co., L SO Jpn. Kokai Tokkyo CODEN: JKXXAF DT Patent LA Japanese FAN.CNT 1 PATENT NO.	LUS trolyte Shimada td., Ja Koho, 4	batteries wi a, Mikiya; Sh pan 7 pp.	th good cycle effici nintani, Takeshi	ency DATE
PI JP 2005285332	A	20051013		20040311

20040301

Α

jan delaval - 8 february 2007

AB The batteries have (A) solid polymer electrolytes containing (a) crosslinked

products of copolymers having repeating units of [CR1R2CR3CO2(CR4aHCR4bHO)mR5] (R1-R3 = H, C1-10 hydrocarbon group; R4a, R4b = H, Me; R5 = H, hydrocarbon group, acyl, silyl; m = 1-100) and (CR6R7CR8R9) (R6, R8 = H, C1-10 hydrocarbon group; R7 = H, C1-10 hydrocarbon group, OH, etc.; R9 = OH, carboxyl, epoxy, etc.), and crosslinking agents, and (b) electrolyte salts, and (B) electrodes containing active mass and block copolymers having blocks of [CR1aR2aCR3aCO2(CR4b1HCR4a1HO)m1R5a] (R1a-R3a = H, C1-10 hydrocarbon group; R4al, R4bl = H, Me; R5a = H, hydrocarbon group, acyl, silyl; ml = 2-100) sandwiched between blocks of (CR6aR7aCR8aR9a) (R6a-R8a = H, C1-10 hydrocarbon group; R9a = aryl). The batteries, having crosslinked ion-conductive copolymers in electrolytes and noncrosslinked ion-conductive copolymers containing same repeating units to the electrolyte copolymers in electrodes, show good discharge capacity and charge-discharge efficiency. ICM H01M0010-40 ICS C08F0297-02 52-2 (Electrochemical, Radiational, and Thermal Energy Technology) Section cross-reference(s): 38 697284-07-4DP, lithium complex RL: DEV (Device component use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses) (comb structure-containing, electrode component; solid polymer electrolyte batteries with good cycle efficiency) 849950-63-6P RL: IMF (Industrial manufacture); RCT (Reactant); PREP (Preparation); RACT (Reactant or reagent) (comb structure-containing; solid polymer electrolyte batteries with good cycle efficiency) 697284-07-4DP, lithium complex RL: DEV (Device component use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses) (comb structure-containing, electrode component; solid polymer electrolyte batteries with good cycle efficiency) 697284-07-4 HCAPLUS Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω methoxy-, polymer with ethenylbenzene, triblock (9CI) (CA INDEX NAME) CM1 CRN 26915-72-0 CMF (C2 H4 O)n C5 H8 O2 CCI PMS

 H_2C O $Me-C-CH_2-CH_2$ OMe

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

ΙÇ

CC

IT

ΙT

IT

RN

CN

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IT 849950-63-6P
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RL: IMF (Industrial manufacture); RCT (Reactant); PREP (Preparation); RACT (Reactant or reagent)

(comb structure-containing; solid polymer electrolyte batteries with good cycle efficiency)

RN 849950-63-6 HCAPLUS

CN 2-Propenoic acid, 2-hydroxyethyl ester, polymer with ethenylbenzene and α -(2-methyl-1-oxo-2-propenyl)- ω -methoxypoly(oxy-1,2-ethanediyl), pentablock (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

CM 2

CRN 818-61-1 CMF C5 H8 O3

CM 3

CRN 100-42-5 CMF C8 H8

 $H_2C \longrightarrow CH - Ph$

L110 ANSWER 6 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

AN 2005:1002575 HCAPLUS

DN 144:394494

TI Characteristics of new-type solid polymer electrolyte controlling nano-structure

AU **Niitani, Takeshi**; Shimada, Mikiya; Kawamura, Kiyoshi; Kanamura, Kiyoshi

CS Nippon Soda Co. Ltd., Ichihara, Chiba, 290-0045, Japan

SO Journal of Power Sources (2005), 146(1-2), 386-390 CODEN: JPSODZ; ISSN: 0378-7753

PB Elsevier B.V.

DT Journal

LA English

AB High ionic conductivity and good mech. properties are needed for solid polymer electrolytes (SPEs) used in solid-state Li polymer batteries. A solid polymer electrolyte with a micro phase separation structure was synthesized and its electrochem. characteristics were studied. The highest value of ionic conductivity was obtained at a concentration of 5 mol% Li salt per ethylene oxide unit.

The ionic conductivity of this SPE was 2 + 10-4 S/cm at 30° . A solid-state Li polymer battery with a composite cathode, Li/SPE/LiCoO2, had good charge/discharge characteristics and retained a discharge capacity of 100 mA-h/g after 100 cycles at room temperature. This SPE was electrochem. stable and did not decompose up to 4.5 V.

CC 52-2 (Electrochemical, Radiational, and Thermal Energy Technology) Section cross-reference(s): 38

IT 112119-04-7P

RL: DEV (Device component use); PNU (Preparation, unclassified); PREP (Preparation); USES (Uses)

(preparation of solid polymer electrolyte with controlled nanostructure for lithium batteries)

IT 112119-04-7P

RL: DEV (Device component use); PNU (Preparation, unclassified); PREP (Preparation); USES (Uses)

(preparation of solid polymer electrolyte with controlled nanostructure for lithium batteries)

RN 112119-04-7 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω methoxy-, polymer with ethenylbenzene, block (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$\begin{array}{c|c} ^{\text{H}_2\text{C}} \circ \\ \parallel & \parallel \\ \text{Me-C-C-C-} - \text{O-CH}_2\text{--CH}_2 - \text{OMe} \end{array}$$

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RETABLE

	(RPY) (RVL) (RPG)	(Referenced File
Armand, M Kamigaito, M Khan, I Matsui, S Ruzette, A Sadoway, D	1979 131 2001 101 3689 1989 190 1069 2001 97-98 772 2001 148 A537 2001 97-98 621		•

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Trapa, P
                        12002 15
                                    1A85
                                           |Electrochem Solid-St|HCAPLUS
Watanabe, M
                        11999 181-821786
                                           | J Power Sources
                                                                 IHCAPLUS
L110 ANSWER 7 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
     2005:967129 HCAPLUS
     144:372906
DN
     Synthesis of Li+ ion conductive PEO-PSt block copolymer electrolyte with
TI
     microphase separation structure
ΑU
     Niitani, Takeshi; Shimada, Mikiya; Kawamura, Kiyoshi; Dokko,
     Kaoru; Rho, Young-Ho; Kanamura, Kiyoshi
CS
     Nippon Soda Company Limited, Ichihara, Chiba, 290-0045, Japan
SO
     Electrochemical and Solid-State Letters (2005), 8(8), A385-A388
     CODEN: ESLEF6; ISSN: 1099-0062
     Electrochemical Society
PB
DT
     Journal
LA
     English
     A block copolymer of polyethylene oxide (PEO) and polystyrene (PSt) was
AB
     used for the preparation of a microphase-separated solid polymer electrolyte
containing
              This electrolyte had an ionic conductivity at room temperature of
     LiClO4.
>10-4 S/cm.
     The polystyrene block provided the mech. strength and the polyethylene
     oxide component allowed fast ion conduction in the electrolyte without any
     plasticizer. A LiCoO2/polymer electrolyte/Li cell was constructed and the
     cell had a discharge capacity of 100 mA-h/g at 30°.
     52-2 (Electrochemical, Radiational, and Thermal Energy Technology)
     Section cross-reference(s): 38, 72
ΙT
     112119-04-7DP, lithium complexes
     RL: DEV (Device component use); SPN (Synthetic preparation); PREP
     (Preparation); USES (Uses)
        (synthesis of Li+-conductive PEO-polystyrene block copolymer
        electrolyte with microphase separation structure for lithium batteries)
     112119-04-7DP, lithium complexes
IT
     RL: DEV (Device component use); SPN (Synthetic preparation); PREP
     (Preparation); USES (Uses)
        (synthesis of Li+-conductive PEO-polystyrene block copolymer
        electrolyte with microphase separation structure for lithium batteries)
RN
     112119-04-7 HCAPLUS
CN
     Poly(oxy-1,2-ethanediyl), \alpha-(2-methyl-1-oxo-2-propenyl)-\omega-
     methoxy-, polymer with ethenylbenzene, block (9CI) (CA INDEX NAME)
     CM
          1
     CRN
          26915-72-0
          (C2 H4 O)n C5 H8 O2
     CMF
     CCI
          PMS
 H<sub>2</sub>C
             о- cн<sub>2</sub>- cн<sub>2</sub>-
     CM
          2
```

100-42-5

C8 H8

CRN CMF $H_2C = CH - Ph$

```
RETABLE
      Referenced Author | Year | VOL | PG | Referenced Work | Referenced
              (RAU) | (RPY) | (RVL) | (RPG) | (RWK) | File
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                             Armand, M
                                                 |1979 | |131 |Fast Ion Transport i|HCAPLUS
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Croce, F
                                                |1995 |
                                                                            1
                                                                                          |Solid State Electroc|
                                                |1998 |394 |456 |Nature (London)
                                                                                                                                          IHCAPLUS
Gadjourova, Z
                                               |2001 |412 |520 |Nature (London)
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Gray, F
                                                |1988 |21 |392 |Macromolecules
|1986 |27 |98 |Polym Commun
                                                                                                                                          HCAPLUS
Hall, P
                                               |1986 |27
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                                       | 1986 | 27 | 196 | FOLYM COMMUNITY | 11011200 | 12001 | 1101 | 13689 | Chem Rev (Washington|HCAPLUS | 11989 | 1190 | 11069 | Makromol Chem | HCAPLUS | 11992 | 137 | 11585 | Electrochim Acta | HCAPLUS | 12001 | 197-98 | 1772 | J Power Sources | HCAPLUS | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137 | 137
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Khan, I
Le Nest, J
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Niitani, T
                                                                                          | J Power Sources, In |
                                        i
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                                                                                                                                           | HCAPLUS
Persi, L
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Sadoway, D
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Watanabe, M
                                                  |1999 |81-82|786 |J Power Sources
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|Polym Int 
                                                                         |597
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Wright, P
                                                   |1998 |47
                                                                                                                                        | HCAPLUS
                                                                             |34
Xia, Y
                                                   |2001 |92
                                                                             1234
                                                                                            | J Power Sources
                                                                                                                                          | HCAPLUS
L110 ANSWER 8 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
           2005:612574 HCAPLUS
DN
           143:136276
ΤI
           Polymer solid electrolytes for batteries
           Shimada, Mikiya; Niitani, Takeshi
ΙN
PΑ
          Nippon Soda Co., Ltd., Japan
SO
           PCT Int. Appl., 33 pp.
           CODEN: PIXXD2
DT
           Patent
LA
           Japanese
FAN.CNT 1
          WO 2005064600
                                                                      DATE
                                                                                             APPLICATION NO.
                                                                                                                                                DATE
                                                                                                -----
           WO 2005064620
                                                      A1 20050714 WO 2004-JP19710
PΙ
                                                                                                                                                20041222
                    W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH,

W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW
RW: BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG

PRAI JP 2003-430626
          JP 2003-430626 A
JP 2004-296309 A
                                                                      20031225
                                                                      20041008
           Disclosed is a polymer solid electrolyte having both excellent ion conductivity
AΒ
```

and shape stability. A polymer solid electrolyte was characterized by containing a polymer having an ion-conducting region, an additive having at least one chemical bond selected from the group consisting of urethane bond, thiourethane bond, ureide bond, imide bond and amide bond in a mol., and an electrolyte salt.

IC ICM H01B0001-06

ICS C08K0003-00; C08K0005-00; C08L0053-00; C08L0055-00; H01M0010-40

CC 52-2 (Electrochemical, Radiational, and Thermal Energy Technology)

Section cross-reference(s): 35

ΙT 9081-45-2P, Styrene-methyl polyethylene glycol monomethacrylate copolymer 858181-45-0P, Styrene-2-hydroxyethyl acrylate-polyethylene glycol monomethacrylate methyl ether copolymer RL: DEV (Device component use); PNU (Preparation, unclassified); PREP (Preparation); USES (Uses)

(polymer solid electrolytes for batteries)

9081-45-2P, Styrene-methyl polyethylene glycol monomethacrylate ΙT copolymer 858181-45-0P, Styrene-2-hydroxyethyl acrylate-polyethylene glycol monomethacrylate methyl ether.copolymer RL: DEV (Device component use); PNU (Preparation, unclassified); PREP (Preparation); USES (Uses)

(polymer solid electrolytes for batteries)

RN 9081-45-2 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω methoxy-, polymer with ethenylbenzene (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

2 CM

CRN 100-42-5 CMF C8 H8

 $H_2C \longrightarrow CH - Ph$

RN 858181-45-0 HCAPLUS

CN 2-Propenoic acid, 2-hydroxyethyl ester, polymer with ethenylbenzene and α -(2-methyl-1-oxo-2-propenyl)- ω -methoxypoly(oxy-1,2ethanediyl) (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI **PMS**

$$\begin{array}{c|c} ^{H_2C} & \text{O} \\ \parallel & \parallel \\ \text{Me-} & \text{C-} & \text{C-} & \text{C-} & \text{CH}_2 - \text{CH}_2 - \text{CH}_2 \\ \end{array} \begin{array}{c} \text{OMe} \\ \end{array}$$

CRN 818-61-1 CMF C5 H8 O3

$$_{\text{HO-CH}_2\text{--CH}_2\text{--O-C-CH}}^{\text{O}}$$

CM 3

CRN 100-42-5 CMF C8 H8

US 2001-826300

US 2004-813221

US 2004-842111

Α2

A2

A2

 $H_2C = CH - Ph$

RETABLE

	(RAU)	(RPY) (RVL) (RPG)	Referenced Work (RWK)	File					
Hitachi Chemical Co Ltd 2001 JP 200143731 A										
L110 ANSWER 9 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN AN 2005:497332 HCAPLUS DN 143:35168 TI Water-developable infrared-sensitive printing plate IN Munnelly, Heidi M.; Wieland, Kevin; Ray, Kevin Barry PA Kodak Polychrome Graphics LLC, USA SO U.S. Pat. Appl. Publ., 14 pp., Contin-part of U.S. Ser. No. 891,727. CODEN: USXXCO DT Patent LA English FAN.CNT 7										
	PATENT NO.	KIND	DATE	APPLICATION NO.						
PI	US 2003064318	A1 A1 B2	20050609 20030403 20050531	US 2004-13954	20041216 <					
ד ג סס	US 2005003285 US 2004260050 US 7172850 US 2002-119454	B2	20050106 20041223 20070206	US 2004-891727						
LVAT	US 2004-872209 US 2004-891727	A2	20020410 20040617 20040715	<						

jan delaval - 8 february 2007

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20010404

20040330

20040510

AB The present invention provides an imageable element including a lithog. substrate and an imageable layer disposed on the substrate. The imageable layer includes a radically polymerizable component, an initiator system capable of generating radicals sufficient to initiate a polymerization reaction upon exposure to imaging radiation, and a polymeric binder having a hydrophobic backbone and including constitutional units having a pendant group including a hydrophilic poly(alkylene oxide) segment. The imageable element can be developed using an aqueous developer solution Alternatively,

the

imageable element can be developed on-press by contact with ink and/or fountain solution

IC ICM G03C0001-76

INCL 430270100

CC 74-6 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes) Section cross-reference(s): 35, 38

IT 9081-45-2P, Poly(ethylene glycol)methyl ether methacrylate-styrene copolymer

RL: PRP (Properties); SPN (Synthetic preparation); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (water-developable IR-sensitive printing plate)

IT 9081-45-2P, Poly(ethylene glycol)methyl ether methacrylate-styrene copolymer

RL: PRP (Properties); SPN (Synthetic preparation); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (water-developable IR-sensitive printing plate)

RN 9081-45-2 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω methoxy-, polymer with ethenylbenzene (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0 CMF (C2 H4 O)n C5 H8 O2 CCI PMS

$$H_2C$$
 O H_2C H_2C

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

L110 ANSWER 10 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN AN 2005:323497 HCAPLUS

DN 142:395064

TI Polymer solid electrolytic electric battery, electrode and those production methods

IN Kanamura, Kiyoshi; Kawamura, Kiyoshi; Shintani, Takeshi; Shimada, Mikiya;

Aoyagi, Koichiro

PA Nippon Soda Co., Ltd., Japan

SO Jpn. Kokai Tokkyo Koho, 40 pp. ·

CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	JP 2005100966	A	20050414	JP 2004-240036	20040819
PRAT	JP 2003-295880	Ά	20030820		

AB The disclosed battery contains polymer electrolyte comprising block copolymer having ethylene glycol derivative-acrylic acid derivative ester polymer

block, and vinyl polymer block(s). The disclosed electrodes for the battery contains electrode active substance, an electrolyte salt, and the block copolymer. Fabrication process for the battery is also disclosed. The polymer electrolyte has excellent thermal stability, phys. properties, and ion conductivity

IC ICM H01M0010-40

ICS C08F0293-00; H01B0001-06; H01M0004-02; H01M0004-04; H01M0004-60

CC 52-2 (Electrochemical, Radiational, and Thermal Energy Technology)

IT 697284-07-4P 849950-63-6P

RL: SPN (Synthetic preparation); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(polymer electrolytes for lithium batteries)

IT 697284-07-4P 849950-63-6P

RL: SPN (Synthetic preparation); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(polymer electrolytes for lithium batteries)

RN 697284-07-4 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω -methoxy-, polymer with ethenylbenzene, triblock (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$H_2C$$
 O $Me-C-C$ CH_2-CH_2 OMe

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 849950-63-6 HCAPLUS

CN 2-Propenoic acid, 2-hydroxyethyl ester, polymer with ethenylbenzene and α -(2-methyl-1-oxo-2-propenyl)- ω -methoxypoly(oxy-1,2-

ethanediyl), pentablock (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$\begin{array}{c|c} ^{H_2C} & \text{O} \\ \parallel & \parallel \\ \text{Me-C-C-C-} & \text{O-CH}_2\text{--CH}_2 \\ \hline \end{array} \right]_n \text{OMe}$$

CM 2

CRN 818-61-1 CMF C5 H8 O3

CM 3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

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L110 ANSWER 11 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
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AN 2005:260319 HCAPLUS

DN 142:339051

TI Composition for polymer solid electrolyte, polymer solid electrolyte, polymer solid electrolyte battery, ion-conductive membrane, copolymer and process for producing the copolymer

IN Muramoto, Hiroo; Niitani, Takeshi; Aoyagi, Koichiro

PA Nippon Soda Co., Ltd., Japan

SO PCT Int. Appl., 128 pp.

CODEN: PIXXD2

DT Patent

LA Japanese

FAN.CNT 1

r s ris .	CIVI	1																
	PATENT NO.					KIND DATE			APPLICATION NO.						DATE			
ΡI	WO	WO 2005027144			A1 20050324		WO 2004-JP576						20040123					
		W:	ΑE,	AG,	AL,	ΑM,	ΑT,	ΑU,	ΑZ,	BA,	BB,	BG,	BR,	BW,	BY,	BZ,	CA,	CH,
			CN,	CO,	CR,	CU,	CZ,	DE,	DK,	DM,	DZ,	EC,	EE.	EG.	ES.	FI.	GB.	GD.
								ID,										
			LR,	LS,	LT,	LU,	LV,	MA,	MD,	MG,	MK,	MN,	MW,	MX,	MZ,	NA.	NI.	NO.
								PT,										
								UA,										,

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RW: BW, GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ,
             BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK, EE,
             ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PT, RO, SE, SI, SK,
             TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG
     JP 2005089510
                          Α
                                 20050407
                                            JP 2003-321155
                                                                    20030912
     EP 1667168
                          A1
                                 20060607
                                            EP 2004-704735
                                                                    20040123
             AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
         R:
             IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU, SK
     CN 1849674
                                             CN 2004-80025920
                                 20061018
                                                                    20040123
PRAI JP 2003-321155
                                 20030912
     WO 2004-JP576
                          W
                                 20040123
AΒ
     Polymer solid electrolytes excelling in thermal properties, phys.
     properties and ion conductivity and being close to practical level for use in
     batteries are disclosed. In particular, a composition for polymer solid
     electrolyte characterized in that the composition contains a copolymer and an
     electrolyte salt, the copolymer having repeating units of the formula:
     [CR1R2CR3CO2(CHR4aCHR4bO)mR5] (R1, R2, R3 = H, C1-C10 hydrocarbyl; R4a,
     R4b = H , Me; Me; R5 = H, hydrocarbyl, acyl, silyl; and m is an integer of
     1 to 100) and repeating units of the formula: CR6R7CR8R9 ( R6, R7, R8 = H,
     C1-C10 hydrocarbyl; R9 = an organic group having at least one functional
     group selected from hydroxyl, carboxyl, epoxy, an acid anhydride group and
     amino).
IC
     ICM H01B0001-06
         C08L0033-14; C08L0053-00; C08F0297-00; H01M0006-18; H01M0010-40;
     ICS
          H01M0004-60
CC
     52-2 (Electrochemical, Radiational, and Thermal Energy Technology)
     Section cross-reference(s): 35
IT
     697284-07-4P 848439-41-8DP, desilylated
                                                848439-42-9DP,
     desilylated 848439-43-ODP, deethylated 848439-44-1DP,
     debutylated
                  848442-02-4DP, desilylated 848442-03-5P
     849950-63-6P 877834-07-6P 877837-29-1DP,
     desilylated
     RL: SPN (Synthetic preparation); TEM (Technical or engineered material
     use); PREP (Preparation); USES (Uses)
        (polymer electrolyte compns. containing)
     697284-07-4P 848439-41-8DP, desilylated
IT
     848439-43-0DP, deethylated 848439-44-1DP, debutylated
     848442-03-5P 849950-63-6P 877834-07-6P
     877837-29-1DP, desilylated
     RL: SPN (Synthetic preparation); TEM (Technical or engineered material
     use); PREP (Preparation); USES (Uses)
        (polymer electrolyte compns. containing)
RN
     697284-07-4 HCAPLUS
CN
     Poly(oxy-1,2-ethanediyl), \alpha-(2-methyl-1-oxo-2-propenyl)-\omega-
     methoxy-, polymer with ethenylbenzene, triblock (9CI) (CA INDEX NAME)
     CM
          1
          26915-72-0
     CMF
          (C2 H4 O)n C5 H8 O2
     CCI
          PMS
Me - C - C - O - CH_2 - CH_2 - OMe
```

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 848439-41-8 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, 2-[(trimethylsilyl)oxy]ethyl ester, polymer with ethenylbenzene and α -(2-methyl-1-oxo-2-propenyl)- ω -methoxypoly(oxy-1,2-ethanediyl), triblock (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0 CMF (C2 H4 O)n C5 H8 O2 CCI PMS

CM 2

CRN 17407-09-9 CMF C9 H18 O3 Si

CM 3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 848439-43-0 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω -methoxy-, polymer with ethenylbenzene and 1-ethenyl-4-(1-ethoxyethoxy)benzene, triblock (9CI) (CA INDEX NAME)

CM 1

CRN 157057-20-0 CMF C12 H16 O2

CRN 26915-72-0

(C2 H4 O)n C5 H8 O2

CCI PMS

$$H_2C$$
 O $Me-C-C$ CH_2-CH_2 OMe

3 CM

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN848439-44-1 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), $\alpha\text{-}(2\text{-methyl-1-oxo-2-propenyl})\text{-}\omega\text{-}$ methoxy-, polymer with 1-butoxy-3-ethenylbenzene and ethenylbenzene, block, graft (9CI) (CA INDEX NAME)

CM1.

CRN 156660-60-5 CMF C12 H16 O

CM

26915-72-0 CRN

CMF (C2 H4 O)n C5 H8 O2

CCI

$$\begin{array}{c|c} \text{H}_2\text{C} & \text{O} \\ \parallel & \parallel \\ \text{Me-C-C} & \text{C-CH}_2\text{--CH}_2 \\ \hline \end{array} \quad \text{OMe}$$

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 848442-03-5 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with ethenylbenzene and $\alpha\text{-}(2\text{-methyl-}1\text{-}oxo\text{-}2\text{-propenyl})\text{-}\omega\text{-}$ methoxypoly(oxy-1,2-ethanediyl), triblock (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0 CMF (C2 H4 O)n C5 H8 O2 CCI PMS

CM 2

CRN 868-77-9 CMF C6 H10 O3

CM 3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 849950-63-6 HCAPLUS

CN 2-Propenoic acid, 2-hydroxyethyl ester, polymer with ethenylbenzene and α -(2-methyl-1-oxo-2-propenyl)- ω -methoxypoly(oxy-1,2-

ethanediyl), pentablock (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$H_2C$$
 O H_2C O H_2C H_2C OMe

CM 2

CRN 818-61-1 CMF C5 H8 O3

CM 3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 877834-07-6 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, oxiranylmethyl ester, polymer with ethenylbenzene and α -(2-methyl-1-oxo-2-propenyl)- ω -methoxypoly(oxy-1,2-ethanediyl), graft (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

CM 2

CRN 106-91-2 CMF C7 H10 O3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 877837-29-1 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, trimethylsilyl ester, polymer with ethenylbenzene and $\alpha\text{-}(2\text{-methyl-1-oxo-2-propenyl})\text{-}\omega\text{-}$ methoxypoly(oxy-1,2-ethanediyl), pentablock (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$H_2C$$
 O H_2C H_2C

CM 2

CRN 13688-56-7 CMF C7 H14 O2 Si

$$\begin{array}{c|c} \text{O} & \text{CH}_2 \\ \parallel & \parallel \\ \text{Me}_3\text{Si-O-C-C-Me} \end{array}$$

CM 3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RETABLE

Referenced Author | Year | VOL | PG | Referenced Work | Referenced (RAU) | (RPY) | (RVL) | (RPG) | (RWK) | File

jan delaval - 8 february 2007

```
Fukoku Co Ltd
Kanemura, K
                       12003 |
                                    153
                                         |Nano Kozo o Seigyo S|
Matsushita Electric Ind|1993 |
                                           |JP 05-120912 A | | HCAPLUS
                                  - -
Nippon Soda Co Ltd | 2004 |
                                          JP 2004107641 A
                                                                 HCAPLUS
                       |2003 | |
|2003 | |53
Nissan Motor Co Ltd
                                          |JP 2003217594 A
                                                                | HCAPLUS
Shimada, M
                                    |53
                                         |Nano Kozo o Seigyo s|
                                   i
Shin-Etsu Chemical Co L|1995 |
                                         |JP 07-109321 A
                                                                | HCAPLUS
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                                          |JP 07-230810 A
                                                                 | HCAPLUS
                       |2003 | |52 |Nano Kozo o Seigyo S|
Shintant, T
Telefonaktiebolaget Lm |2003 |
                                          |WO 0146280 A1
                                  - 1
                                                                | HCAPLUS
Telefonaktiebolaget Lm |2003 |
                                           |US 20010033974 A1
                                                                 Telefonaktiebolaget Lm |2003 |
                                           JP 2003518172 A
                    [2002]
Ube Industries Ltd
                                           |JP 2002260441 A
                                                                | HCAPLUS
Ube Industries Ltd
                      |2003 |
                                           |JP 200345226 A
L110 ANSWER 12 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
     2005:15851 HCAPLUS
ΤI
     Imageable element with solvent-resistant polymeric binder for lithographic
     printing plate substrate
ΙN
     Hayashi, Kouji; Munnelly, Heidi M.; Tao, Ting; Huang, Jianbing; Saraiya,
     Shashikant
PA
     Kodak Polychrome Graphics LLC, Japan
SO
     U.S. Pat. Appl. Publ., 18 pp., Cont.-in-part of U.S. Ser. No. 842,111.
     CODEN: USXXCO
DT
     Patent
T.A
     English
FAN.CNT 7
     PATENT NO.
                        KIND DATE
                                            APPLICATION NO.
                                                                     DATE
                         ____
                                 -----
PΙ
     US 2005003285
                          A1
                                 20050106
                                             US 2004-872209
                                                                     20040617 <--
     US 2002155375
                                          US 2001-826300
                          A1
                                 20021024
                                                                     20010404 <--
     US 6582882
                                 20030624
                          B2
     US 2003064318
                          Α1
                                 20030403
                                            US 2002-119454
                                                                     20020410 <--
     US 6899994
                          B2
                                 20050531
     US 2005221215
                          A1
                                 20051006
                                             US 2004-813221
                                                                     20040330 <--
     US 7049046
                          B2
                                 20060523
     US 2005250040
                          A1
                                 20051110
                                             US 2004-842111
                                                                     20040510 <--
     US 7045271
                          В2
                                 20060516
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                                 20041223
                                             US 2004-891727
                                                                     20040715 <--
     US 7172850
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                         A1
                                 20050609
                                             US 2004-13954
                                          US 2004-1332
WO 2005-US19391
                                                                     20041216 <--
     WO 2006007270
                          Α1
                                 20060119
                                                                    20050602 <--
            AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH,
             CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KM, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NG, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SM, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU,
             ZA, ZM, ZW
         RW: AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE,
             IS, IT, LT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR, BF, BJ, CF,
             CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG, BW, GH, GM,
             KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ, BY, KG,
             KZ, MD, RU, TJ, TM
PRAI US 2001-826300
                                 20010404
                          A2
                                           <--
     US 2002-119454
                          A2
                                 20020410
                                          <--
     US 2004-813221
                          A2
                                 20040330
                                          <--
     US 2004-842111
                          A2
                                 20040510
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US 2004-872209 A2 20040617 <--
US 2004-891727 A2 20040715 <--
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The present invention provides an imageable element including a lithog. substrate and an imageable layer disposed on the substrate. The imageable layer includes a radically polymerizable component, an initiator system capable of generating radicals sufficient to initiate a polymerization reaction upon exposure to imaging radiation, and a polymeric binder having a hydrophobic backbone and including both constitutional units having a pendant cyano group attached directly to the hydrophobic backbone, and constitutional units having a pendant group including a hydrophilic poly(alkylene oxide) segment. When the imageable element is imaged and developed, the resulting printing plate may exhibit improved on-press solvent resistance and longer press life.

IC ICM G03C0001-76

INCL 430056000; X43-030.0

CC 74-6 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)
Section cross-reference(s): 35, 38

9081-45-2P, Poly(ethylene glycol)methyl ether methacrylate-styrene copolymer 100481-51-4P, Acrylonitrile-polyethylene glycol monomethyl ether methacrylate-styrene copolymer 123547-25-1P, Allyl methacrylate-polyethylene glycol monomethyl ether methacrylate copolymer 155620-12-5P 820260-75-1P, Methacrylonitrile-polyethylene glycol monomethyl ether methacrylate-styrene copolymer RL: NUU (Other use, unclassified); PRP (Properties); SPN (Synthetic preparation); PREP (Preparation); USES (Uses)

(Imageable element with solvent-resistant polymeric binder for lithog. printing plate substrate)

IT 9081-45-2P, Poly(ethylene glycol)methyl ether methacrylate-styrene copolymer

RL: NUU (Other use, unclassified); PRP (Properties); SPN (Synthetic preparation); PREP (Preparation); USES (Uses)

(Imageable element with solvent-resistant polymeric binder for lithog. printing plate substrate)

RN 9081-45-2 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω -methoxy-, polymer with ethenylbenzene (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0 CMF (C2 H4 O)n C5 H8 O2 CCI PMS

$$\begin{array}{c|c} ^{\text{H}_2\text{C}} & \text{O} \\ \parallel & \parallel \\ \text{Me-C-C} & \text{C-CH}_2 - \text{CH}_2 - \text{CH}_2 \\ \end{array} \right] \text{OMe}$$

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

```
L110 ANSWER 13 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
     2004:80751 HCAPLUS
ΑN
DN
     140:149116
TI
     Solid polymer electrolyte
IN
     Muramoto, Hiroo; Niitani, Takeshi
PA
     Nippon Soda Co., Ltd., Japan
SO
     PCT Int. Appl., 54 pp.
     CODEN: PIXXD2
DT
     Patent
LA
     .
Japanese
FAN.CNT 1
     PATENT NO.
                          KIND
                                 DATE
                                             APPLICATION NO.
                                                                      DATE
     -----
                          ____
                                 -----
                                              -----
PΙ
     WO 2004009663
                          A1
                                 20040129
                                              WO 2003-JP9328
                                                                      20030723 <--
         W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH, CN,
             CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, ES, FI, GB, GD, GE, GH,
             GM, HR, HU, ID, IL, IN, IS, KE, KG, KP, KR, KZ, LC, LK, LR, LS,
             LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NI, NO, NZ, OM, PG,
             PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR,
             TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW
         RW: GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ, BY,
             KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES,
             FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PT, RO, SE, SI, SK, TR,
             BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG
     AU 2003252245
                                 20040209
                                             AU 2003-252245
                           Α1
                                                                      20030723 <--
     JP 2004107641
                                              JP 2003-200804
                           Α
                                 20040408
                                                                      20030723 <--
                                              EP 2003-765362
     EP 1553117
                                 20050713
                           A1
                                                                      20030723 <--
     EP 1553117
                           В1
                                 20070117
             AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT, IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU, SK
     CN 1668662
                           Α
                                 20050914
                                             CN 2003-817326
                                                                      20030723 <--
     US 2005256256
                                 20051117
                           Α1
                                              US 2005-523085
                                                                      20050202 <--
PRAI JP 2002-214603
                           Α
                                 20020723
                                            <---
     WO 2003-JP9328
                           W
                                 20030723
GΙ
```

$$\begin{array}{c|cccc}
R^1 & R^3 \\
\hline
C & C & C \\
R^2 & C & C
\end{array}$$

$$\begin{array}{c|ccccc}
C & C & C & C \\
C & C & C & C
\end{array}$$

$$\begin{array}{c|ccccc}
C & C & C & C
\end{array}$$

$$\begin{array}{c|ccccc}
C & C & C & C
\end{array}$$

$$\begin{array}{c|ccccc}
C & C & C & C
\end{array}$$

$$\begin{array}{c|ccccc}
C & C & C & C
\end{array}$$

$$\begin{array}{c|ccccc}
C & C & C & C
\end{array}$$

$$\begin{array}{c|ccccc}
C & C & C & C
\end{array}$$

$$\begin{array}{c|ccccc}
C & C & C
\end{array}$$

$$\begin{array}{c|cccccc}
C & C & C
\end{array}$$

$$\begin{array}{c|cccccc}
C & C & C
\end{array}$$

$$\begin{array}{c|ccccccc}
C & C & C
\end{array}$$

$$\begin{array}{c|cccccc}
C & C & C
\end{array}$$

AB The present invention relates to (i) a solid polymer **electrolyte** which is excellent in thermal properties, phys. properties, and ionic conductivity and is on a level close to a practical level, especially a wholly solid

electrolyte and (ii) a copolymer composition serving as a base for
producing the electrolyte. The solid polymer
electrolyte comprises (A) a copolymer comprising a block chain A
comprising repeating units I, a block chain B comprising repeating units

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ΙT

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ΙT

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IT

ΙT

IT

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(CR6R7CR8R9), and a block chain C comprising repeating units
(CR10R11CR12R13), these chains being arranged in the order of B, A, and C,
and (B) an electrolyte salt, wherein R1, R2, R3 = independently
H or C1-10 hydrocarbon, R1 and R3 may form a ring; R4a, R4b =
independently H or methyl; R5 = H, hydrocarbon, acyl, or silyl group; R6,
R7, R8, R10, R11, R12 = independently H or C1-10 hydrocarbon; R9 = aryl;
R13 = aryl or heteroaryl; and m = 2-100 integer. Thus, 22.35 g Blemmer
PME 1000 was polymerized in the presence of dichlorotris(triphenylphosphine)ru
thenium, di-n-butylamine, and 2,2-dichloroacetophenone to give a polymer
with Mn 122,500, 6.13 g of which was polymerized with 2.60 g styrene to give a
styrene-polyoxyalkylene graft block copolymer with Mn 135,000, 1 g of
which was mixed with 0.09 g lithium perchlorate, cast on a Teflon plat,
and dried at room temperature for 24 h and 60° for 24 h to give a solid
polymer electrolyte with ionic conductivity 3.8 + 10-4 S/cm at
23°.
ICM C08F0297-00
ICS H01B0001-06
52-2 (Electrochemical, Radiational, and Thermal Energy Technology)
Section cross-reference(s): 38
solid polymer electrolyte; styrene Blemmer graft block copolymer
lithium perchlorate solid electrolyte
Membranes, nonbiological
   (elec. conductive; preparation of solid polymer electrolytes with
   good thermal properties, phys. properties, and ionic conductivity)
Acids, uses
Alkali metal salts
Phosphonium compounds
Quaternary ammonium compounds, uses
Transition metal salts
RL: MOA (Modifier or additive use); USES (Uses)
   (electrolytic salts; preparation of solid polymer
   electrolytes with good thermal properties, phys. properties,
   and ionic conductivity)
Secondary batteries
   (lithium; preparation of solid polymer electrolytes with good
   thermal properties, phys. properties, and ionic conductivity)
Polymerization
   (living, radical; preparation of solid polymer electrolytes with
   good thermal properties, phys. properties, and ionic conductivity)
Ionic conductors
   (polymeric; preparation of solid polymer electrolytes
   with good thermal properties, phys. properties, and ionic conductivity)
Polyoxyalkylenes, uses
RL: IMF (Industrial manufacture); POF (Polymer in formulation); PRP
(Properties); TEM (Technical or engineered material use); PREP
(Preparation); USES (Uses)
   (polystyrene-, block, graft, lithium complexes; preparation of solid polymer
   electrolytes with good thermal properties, phys. properties,
   and ionic conductivity)
Polymer electrolytes
   (preparation of solid polymer electrolytes with good thermal
   properties, phys. properties, and ionic conductivity)
9003-53-6P, Styrene homopolymer 87105-87-1P, Blemmer PME 1000
homopolymer
RL: IMF (Industrial manufacture); RCT (Reactant); PREP (Preparation); RACT
(Reactant or reagent)
   (intermediate, living polymer; preparation of solid polymer
   electrolytes with good thermal properties, phys. properties,
   and ionic conductivity)
7439-93-2DP, Lithium, polyoxyalkylene complexes, perchlorate-containing
```

```
RL: IMF (Industrial manufacture); POF (Polymer in formulation); PRP
     (Properties); TEM (Technical or engineered material use); PREP
     (Preparation); USES (Uses)
        (preparation of solid polymer electrolytes with good thermal
        properties, phys. properties, and ionic conductivity)
ΙT
     846568-02-3P, Ethylene oxide-styrene triblock graft copolymer
     RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical or
     engineered material use); PREP (Preparation); USES (Uses)
        (preparation of solid polymer electrolytes with good thermal
        properties, phys. properties, and ionic conductivity)
     112119-04-7DP, lithium complexes, perchlorate-containing
ΙT
     112119-04-7P 651724-21-9P 697284-07-4P
     846569-40-2P
     RL: IMF (Industrial manufacture); POF (Polymer in formulation); TEM
     (Technical or engineered material use); PREP (Preparation); USES (Uses)
        (triblock; preparation of solid polymer electrolytes with good
        thermal properties, phys. properties, and ionic conductivity)
TΤ
     651724-21-9DP, lithium complexes, perchlorate-containing
     697284-07-4DP, lithium complexes, perchlorate-containing
     846569-40-2DP, lithium complexes, perchlorate-containing
     RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical or
     engineered material use); PREP (Preparation); USES (Uses)
        (triblock; preparation of solid polymer electrolytes with good
        thermal properties, phys. properties, and ionic conductivity)
     846568-02-3P, Ethylene oxide-styrene triblock graft copolymer
IT
     RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical or
     engineered material use); PREP (Preparation); USES (Uses)
        (preparation of solid polymer electrolytes with good thermal
        properties, phys. properties, and ionic conductivity)
RN
     846568-02-3 HCAPLUS
CN
     Oxirane, polymer with ethenylbenzene, graft, triblock (9CI) (CA INDEX
     NAME)
     CM
          1
     CRN
         100-42-5
     CMF C8 H8
H_2C = CH - Ph
     CM
          2
     CRN
         75-21-8
     CMF C2 H4 O
     112119-04-7DP, lithium complexes, perchlorate-containing
```

IT

112119-04-7P 651724-21-9P 697284-07-4P 846569-40-2P RL: IMF (Industrial manufacture); POF (Polymer in formulation); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (triblock; preparation of solid polymer electrolytes with good thermal properties, phys. properties, and ionic conductivity)

bernshteyn - 10 / 523085 RN112119-04-7 HCAPLUS Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω -CN methoxy-, polymer with ethenylbenzene, block (9CI) (CA INDEX NAME) CM CRN 26915-72-0 CMF (C2 H4 O)n C5 H8 O2 CCI PMS H₂C - o- сн₂- сн₂-CM2 CRN 100-42-5 CMF C8 H8 $H_2C = CH - Ph$ RN112119-04-7 HCAPLUS CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω -

CN Poly(oxy-1,2-ethanediyl), α-(2-methyl-1-oxo-2-propenyl)-ω-methoxy-, polymer with ethenylbenzene, block (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0 CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$H_2C$$
 O H_2C H_2C

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 651724-21-9 HCAPLUS CN Poly(oxy-1,2-ethanediyl), α -(1-oxo-2-propenyl)- ω -methoxy-, polymer with ethenylbenzene, block (9CI) (CA INDEX NAME)

CM 1

```
CRN 32171-39-4
CMF (C2 H4 O)n C4 H6 O2
CCI PMS
```

$$H_2C = CH - C - CH_2 - CH_2 - CH_2 - OMe$$

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 697284-07-4 HCAPLUS CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω -methoxy-, polymer with ethenylbenzene, triblock (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0 CMF (C2 H4 O)n C5 H8 O2 CCI PMS

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 846569-40-2 HCAPLUS CN Poly(oxy-1,2-ethanediyl), α -(1-oxo-2-propenyl)- ω -methoxy-, polymer with ethenylbenzene, triblock (9CI) (CA INDEX NAME)

CM 1

CRN 32171-39-4

CMF (C2 H4 O)n C4 H6 O2

CCI PMS

$$H_2C = CH - C - CH_2 - CH_2 - CH_2 - OMe$$

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

IT 651724-21-9DP, lithium complexes, perchlorate-containing
697284-07-4DP, lithium complexes, perchlorate-containing
846569-40-2DP, lithium complexes, perchlorate-containing
RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical or
engineered material use); PREP (Preparation); USES (Uses)
 (triblock; preparation of solid polymer electrolytes with good
 thermal properties, phys. properties, and ionic conductivity)
RN 651724-21-9 HCAPLUS
CN Poly(oxy-1,2-ethanediyl), α-(1-oxo-2-propenyl)-ω-methoxy-,
polymer with ethenylbenzene, block (9CI) (CA INDEX NAME)

CM 1

CRN 32171-39-4 CMF (C2 H4 O)n C4 H6 O2 CCI PMS

$$H_2C = CH - C - CH_2 - CH_2 - OMe$$

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 697284-07-4 HCAPLUS CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω -methoxy-, polymer with ethenylbenzene, triblock (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0 CMF (C2 H4 O)n C5 H8 O2 CCI PMS

$$\begin{array}{c|c} H_2C & O \\ \hline \parallel & \parallel & \\ Me-C-C-C- & O-CH_2-CH_2- \\ \hline \end{array} \quad OMe$$

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 846569-40-2 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(1-oxo-2-propenyl)- ω -methoxy-, polymer with ethenylbenzene, triblock (9CI) (CA INDEX NAME)

CM 1

CRN 32171-39-4

CMF (C2 H4 O)n C4 H6 O2

CCI PMS

$$H_2C = CH - C - CH_2 - CH_2 - CH_2 - OMe$$

CM 2

CRN 100-42-5 CMF C8 H8

H₂C== CH- Ph

RETABLE

Referenced Author (RAU)	(RPY) (RVL) (RPG)		Referenced File
Shin-Etsu Chemical Co I		JP 10-208545 A	HCAPLUS
Shin-Etsu Chemical Co I		JP 10-237143 A	HCAPLUS
Shin-Etsu Chemical Co I		US 6096234 A1	HCAPLUS
Shin-Etsu Chemical Co I		JP 11-43523 A	HCAPLUS
Ube Industries Ltd		JP 03-196407 A	HCAPLUS

L110 ANSWER 14 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

AN 2003:754853 HCAPLUS

DN 139:261658

Manufacture of polymer dispersions as additives for building materials IN Koppers, Markus; Pakusch, Joachim; Anders, Hermann; Schmidt, Marco; Denu,

```
Hans-Juergen
PA
     BASF Aktiengesellschaft, Germany
     Eur. Pat. Appl., 17 pp.
     CODEN: EPXXDW
DT
     Patent
LA
    German
FAN.CNT 1
     PATENT NO.
                       KIND
                               DATE
                                         APPLICATION NO.
                                                                DATE
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                                           -----
                        ----
                               _____
    EP 1347002
PI
                        A2
                               20030924
                                           EP 2003-3881
                                                                  20030221 <--
     EP 1347002
                        A3 20050713
            AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
             IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU, SK
     DE 10213026
                        A1
                               20031002
                                          DE 2002-10213026
                                                                  20020322 <--
     US 6809148
                         В1
                               20041026
                                           US 2003-383609
                                                                  20030310 <--
     JP 2003301015
                        Α
                               20031021
                                           JP 2003-78366
                                                                  20030320 <--
PRAI DE 2002-10213026
                               20020322 <--
                        Α
     Acrylic copolymer dispersions, useful for improving tensile strength and
     elongation of hydraulic building materials, especially cement, are
manufactured by
     copolymn. of conjugated aliphatic dienes with vinyl aromatic monomers,
     (meth)acrylate esters of C2-10 alkanediols and/or (meth)acrylate esters of
     poly(ethylene glycol) alkyl ethers CH2:CR1CO2(CH2CH2O)nR2 (\overline{R}1 = H, Me; R2
     = C1-4 alkyl; n = 1-100), and optionally, other ethylenically unsatd.
     monomers. A typical title dispersion was manufactured by radical emulsion
     polymerization of hydroxyethyl acrylate, styrene and butadiene in the presence
of
     polystyrene seed emulsion and polyethylene glycol allyl ether as
     copolymerizable emulsifier.
IC
     ICM C08F0220-12
     ICS C08F0220-18; C08J0003-00; C04B0024-26
CC
     35-4 (Chemistry of Synthetic High Polymers)
     Section cross-reference(s): 58
IT
     26354-04-1P, Butadiene-Hydroxyethyl acrylate-Styrene copolymer
     35428-64-9P, Acrylic acid-Butadiene-Hydroxyethyl acrylate-Styrene
     copolymer 602125-14-4P 602125-23-5P
     RL: IMF (Industrial manufacture); TEM (Technical or engineered material
     use); PREP (Preparation); USES (Uses)
        (aqueous dispersion; manufacture of polymer dispersions as additives for
       hydraulic building materials)
IT
     602125-14-4P 602125-23-5P
     RL: IMF (Industrial manufacture); TEM (Technical or engineered material
     use); PREP (Preparation); USES (Uses)
        (aqueous dispersion; manufacture of polymer dispersions as additives for
       hydraulic building materials)
RN
     602125-14-4 HCAPLUS
     2-Propenoic acid, 2-hydroxyethyl ester, polymer with 1,3-butadiene,
CN
     ethenylbenzene and oxirane, graft (9CI) (CA INDEX NAME)
    CM
    CRN
        818-61-1
    CMF C5 H8 O3
```

CRN 106-99-0 CMF C4 H6

 $H_2C \longrightarrow CH - CH \longrightarrow CH_2$

CM 3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

CM 4

CRN 75-21-8 CMF C2 H4 O

 $\stackrel{\circ}{\triangle}$

RN 602125-23-5 HCAPLUS

CN 2-Propenoic acid, 2-hydroxyethyl ester, polymer with 1,3-butadiene, ethenylbenzene, methyloxirane and oxirane, graft (9CI) (CA INDEX NAME)

CM 1

CRN 818-61-1 CMF C5 H8 O3

 $\begin{array}{c} \text{O} \\ || \\ \text{HO-CH}_2\text{-CH}_2\text{-O-C-CH} \end{array} \\ \text{CH}_2$

CM 2

CRN 106-99-0 CMF C4 H6

 $H_2C = CH - CH = CH_2$

CM 3

CRN 100-42-5

CMF C8 H8

 $H_2C = CH - Ph$

CM 4

CRN 75-56-9 CMF C3 H6 O



CM 5

CRN 75-21-8 CMF C2 H4 O

2003:219699 HCAPLUS



DN 138:239509 TIColored fine particle dispersion and a water-based ink for an ink-jet system IN Ninomiya, Hidetaka; Ando, Hiroaki PA Konica Corporation, Japan SO Eur. Pat. Appl., 16 pp. CODEN: EPXXDW DT Patent LA English FAN.CNT 1 PATENT NO. KIND DATE APPLICATION NO. DATE ----______ PΙ EP 1293544 A1 20030319 EP 2002-19826 20020906 <--EP 1293544 В1 20050216 AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT, IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, SK US 2003055115 Α1 20030320 US 2002-237433 20020906 <--JP 2003238872 Α 20030827 JP 2002-266638 20020912 <--PRAI JP 2001-281321 Α 20010917 <--JP 2001-379785 Α 20011213 <--A water-based ink for ink-jet printing comprises colored particles containing: (a) a core particle having a colorant; and (b) a shell having a resin and encapsulating the core particle, wherein the resin comprises a monomer unit having a hydroxyl group in an amount of 0.1 to 50 weight% based on the total weight of the shell. A colored fine particle was prepared by mixing polyvinyl butyral and C.I. Solvent Blue 70 to form a core, then polymerizing a shell layer from styrene and 2-hydroxyethyl methacrylate. ICM C09D0011-00 IC

L110 ANSWER 15 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

ICS C09D0011-02

CC 42-12 (Coatings, Inks, and Related Products)

IT 26010-51-5P, 2-Hydroxyethylmethacrylate-styrene copolymer

78736-61-5P, Polyethyleneglycol monomethacrylate-styrene copolymer

RL: IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(encapsulant; colored fine particle dispersion and a water-based ink for an ink-jet system)

IT 78736-61-5P, Polyethyleneglycol monomethacrylate-styrene copolymer

RL: IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(encapsulant; colored fine particle dispersion and a water-based ink
for an ink-jet system)

RN 78736-61-5 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω -hydroxy-, polymer with ethenylbenzene (9CI) (CA INDEX NAME)

CM 1

CRN 25736-86-1

CMF (C2 H4 O)n C4 H6 O2

CCI PMS

$$\begin{array}{c|c} H_2C & O \\ \parallel & \parallel & \\ Me-C-C & \boxed{ O-CH_2-CH_2- \\ n & \end{array} }$$
 OH

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RETABLE

Referenced Author (RAU)	Year VOL (RPY) (RVL)	(RPG)	eferenced Work (RWK)	Referenced File
Cabot Corp Ciba Sc Holding Ag Ishizuka, T	2001 2000 2001		0130919 A 0053597 A 2001020056 A1	HCAPLUS HCAPLUS
Lansell, N	1997	i iwo	9723575 A	HCAPLUS
Siemensmeyer, K	12002	I I WO	0218504 A	HCAPLUS
Wickramanayake, P	11996	l lus	5531816 A	THCAPLUS

L110 ANSWER 16 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

AN 2002:793939 HCAPLUS

DN 137:317961

TI Thermally imageable lithographic printing plate comprising graft polymer

IN Pappas, S. Peter; Saraiya, Shashikant

PA Kodak Polychrome Graphics, L.L.C., USA

SO PCT Int. Appl., 56 pp.

CODEN: PIXXD2

DT Patent

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LA
     English
FAN.CNT 7
     PATENT NO.
                        KIND
                               DATE
                                           APPLICATION NO.
                                                                  DATE
                        ____
                               -----
                                           -----
                                                                  _____
     WO 2002082180
                        A1
                               20021017
                                           WO 2002-US1929
                                                                  20020123 <--
        W: JP
         RW: AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL,
             PT, SE, TR
     US 2002155375
                         A1
                               20021024
                                           US 2001-826300
                                                                  20010404 <--
     US 6582882
                        В2
                               20030624
     EP 1379918
                         A1
                               20040114
                                          EP 2002-702061
                                                                  20020123 <--
        R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
             IE, FI, CY, TR
     JP 2004525420
                         Т
                               20040819
                                          JP 2002-579886
                                                                  20020123 <--
PRAI US 2001-826300
                        Α
                               20010404 <--
     WO 2002-US1929 W
                               20020123 <--
     The present invention provides a thermally imageable composition that is useful
AB
     in thermal imaging of, for example, lithog. plates and printed circuit
     boards. The imageable element comprises a substrate and a thermally
     imageable composition which includes a graft copolymer having hydrophobic and
     hydrophilic segments. Upon imagewise exposure to thermal energy, the
     graft copolymer produces exposed regions that are less soluble in a developer
     than the unexposed regions. Also included is a method of producing an
     imaged element which includes a graft copolymer according to the present
     invention. The graft copolymers of present invention can be imaged
     without a binder. Furthermore, the thermally imageable compns. can be
     imaged and developed without the need of an intermediate pre-heat step.
     In addition, the present invention does not require the use of an
     intermediate barrier or a covering layer.
IC
     ICM G03C0001-73
     ICS G03C0001-76; G03F0007-038; G03F0007-09; G03F0007-30
CC
     74-6 (Radiation Chemistry, Photochemistry, and Photographic and Other
     Reprographic Processes)
     Section cross-reference(s): 37, 38
     25133-97-5P, Ethyl acrylate-methacrylic acid-methyl methacrylate copolymer
IT
     115115-55-4P 167699-23-2P 176779-38-7P,
     Oxirane-styrene graft copolymer, methyl ether 470696-94-7P
     470702-38-6P, Oxirane-styrene graft copolymer, dodecyl ether
     RL: SPN (Synthetic preparation); TEM (Technical or engineered material
     use); PREP (Preparation); USES (Uses)
        (thermally imageable lithog. printing plate comprising graft polymer)
ΙT
     115115-55-4P 167699-23-2P
     RL: SPN (Synthetic preparation); TEM (Technical or engineered material
     use); PREP (Preparation); USES (Uses)
        (thermally imageable lithog. printing plate comprising graft polymer)
RN
     115115-55-4 HCAPLUS
CN
     Poly(oxy-1,2-ethanediyl), \alpha-(2-methyl-1-oxo-2-propenyl)-\omega-
     methoxy-, polymer with ethenylbenzene, graft (9CI) (CA INDEX NAME)
     CM
     CRN
         26915-72-0
    CMF
          (C2 H4 O)n C5 H8 O2
    CCI
         PMS
```

$$H_2C$$
 O H_2C H_2C

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 167699-23-2 HCAPLUS CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω - (dodecyloxy)-, polymer with ethenylbenzene, graft (9CI) (CA INDEX NAME)

CM 1

CRN 50977-30-5

CMF (C2 H4 O)n C16 H30 O2

CCI PMS

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RETABLE

Referenced Author (RAU)	Year		Referenced File
Fuji Photo Film Co Ltd		EP 0510646 A1	HCAPLUS
Higashi		DE 4108496 A1	HCAPLUS

L110 ANSWER 17 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

AN 2002:364030 HCAPLUS

DN 136:370519

TI (meth)acrylate ester-based resin composition

IN Nakamura, Kazuhiko; Yokota, Yoshiyuki; Takahashi, Kunio; Yoshida, Masaya

PA Nippon Shokubai Co., Ltd., Japan

SO Eur. Pat. Appl., 42 pp.

CODEN: EPXXDW

DT Patent

```
LA
   English
FAN.CNT 1
    PATENT NO.
                        KIND
                               DATE
                                           APPLICATION NO.
                                                                 DATE
    -----
                        ----
                               -----
                                           ----
                                                                 _____
                        A1 20020515 EP 2001-120149
    EP 1205498
PΤ
                                                                 20010822 <--
        R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
            IE, SI, LT, LV, FI, RO, MK, CY, AL, TR
    US 2002091197
                        A1
                                           US 2001-938652
                               20020711
                                                                 20010827 <--
    US 6489396
                        B2
                               20021203
    JP 2002206042
                        Α
                               20020726
                                          JP 2001-258441
                                                                 20010828 <--
PRAI JP 2000-345966
                        Α
                               20001113 <--
    A novel (meth)acrylate ester-based resin composition, which exhibits various
    good properties and is useful in paints, adhesives, and fiber-processing
    materials, comprises a (meth)acrylate ester-based polymer and a
    crosslinking agent, wherein the (meth)acrylate ester-based polymer is
    obtained by polymerizing a monomer component including an alkylcyclohexylalkyl
     (meth) acrylate as an essential component and has a reactive group wherein
    the crosslinking agent has at least two functional groups that are
    reactable with the reactive group in the polymer.
IC
    ICM C08F0220-18
    37-6 (Plastics Manufacture and Processing)
    Section cross-reference(s): 38, 42
ΙT
    402865-15-0P 425409-61-6P 425409-62-7P
                                             425414-27-3P
    425414-29-5P
    RL: IMF (Industrial manufacture); MOA (Modifier or additive use); PREP
     (Preparation); USES (Uses)
        ((meth)acrylate ester-based resin composition)
TΤ
    425409-61-6P 425409-62-7P 425414-29-5P
    RL: IMF (Industrial manufacture); MOA (Modifier or additive use); PREP
     (Preparation); USES (Uses)
        ((meth)acrylate ester-based resin composition)
RN
    425409-61-6 HCAPLUS
    Oxazole, 4,5-dihydro-2-(1-methylethenyl)-, polymer with
CN
    \alpha-(1-oxo-2-propenyl)-\omega-methoxypoly(oxy-1,2-ethanediyl), graft
     (9CI) (CA INDEX NAME)
    CM
         1
    CRN 32171-39-4
         (C2 H4 O)n C4 H6 O2
    CMF
    CCI
         PMS
```

$$H_2C = CH - C - CH_2 - CH_2 - OMe$$

CM 2
CRN 10471-78-0
CMF C6 H9 N O

RN425409-62-7 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, (4-methylcyclohexyl)methyl ester, polymer with 4,5-dihydro-2-(1-methylethenyl)oxazole and α -(1-oxo-2-propenyl)ω-methoxypoly(oxy-1,2-ethanediyl), graft (9CI) (CA INDEX NAME)

CM 1

CRN 364753-38-8 CMF C12 H20 O2

CM 2

CRN 32171-39-4

 CMF (C2 H4 O)n C4 H6 O2

CCI PMS

$$H_2C = CH - C - CH_2 - CH_2 - CH_2 - OMe$$

CM3

CRN 10471-78-0

CMF C6 H9 N O

RN 425414-29-5 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, (4-methylcyclohexyl)methyl ester, polymer with 4,5-dihydro-2-(1-methylethenyl)oxazole and oxirane, methyl ether, graft (9CI) (CA INDEX NAME)

CRN 67-56-1 CMF C H4 O

 ${\rm H}_{\rm 3C}-{\rm OH}$

CM 2

CRN 425414-28-4

CMF (C12 H20 O2 . C6 H9 N O . C2 H4 O) x

CCI PMS

CM 3

CRN 364753-38-8 CMF C12 H20 O2

CM 4

CRN 10471-78-0 CMF C6 H9 N O

CM 5

CRN 75-21-8 CMF C2 H4 O

 $/^{\circ}$

RETABLE

Referenced Author | Year | VOL | PG | Referenced Work | Referenced (RAU) | (RPY) | (RVL) | (RPG) | (RWK) | File

jan delaval - 8 february 2007

```
Bayer
Chisso Corp
                       |1956 | | |FR 1119407 A |
                                           |GB 2253208 A
                        |1992 |
                                                               | HCAPLUS
L110 ANSWER 18 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
     2001:396495 HCAPLUS
AN
DN
     135:20410
TI
     Compatibilizing agent for radical-copolymerizable unsaturated resin
     composition, molding material, and molded article
IN
     Yasumura, Takashi; Takano, Akira
     Dainippon Ink and Chemicals, Inc., Japan
PA
SO
     Eur. Pat. Appl., 24 pp.
     CODEN: EPXXDW
DT
     Patent
LA
     English
FAN.CNT 1
     PATENT NO.
                  KIND DATE APPLICATION NO.
                                                                   DATE
                        ----
     _____
                                            -----
                                                                   -----
     EP 1103569 A2 20010530 EP 2000-124393 20001121 <-- EP 1103569 A3 20040317
PΙ
         R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
             IE, SI, LT, LV, FI, RO
CA 2325972 A1 20010524 CA
US 6670428 B1 20031230 US
NO 2000005914 A 20010525 NO
JP 2001213967 A 20010807 JP
CN 1306017 A 20010801 CN
US 2002111429 A1 20020815 US
US 6815499 B2 20041109
PRAI JP 1999-332664 A 19991124 <--
US 2000-712161 A3 20001115 <--
     CA 2325972
                                             CA 2000-2325972
                                                                     20001114 <--
                                             US 2000-712161
                                                                    20001115 <--
                                                              20001122 <--
20001122 <--
20001124 <--
20020214 <--
                                           NO 2000-5914
                                            JP 2000-355766
                                             CN 2000-137390
                                           US 2002-73926
     A compatibilizing agent, for compatibilizing a radically copolymerizable
AΒ
     unsatd. resin with an addition polymerized polymer, is a graft copolymer which
     contains a styrene monomer as a principal component, and has a principal
     chain consisting of a copolymer with a (meth)acrylate monomer and a side
     chain selected from a ring-opening polymerized polyether side chain consisting
     of a polyoxyalkylene ether, a polyester side chain, and a polycarbonate
     side chain. A radically copolymerizable unsatd. resin composition comprises
     the compatibilizing agent, an addition polymerized polymer, a radically
     copolymerizable unsatd. resin, and a polymerizable unsatd. monomer.
     Molded articles from the composition is also claimed.
IC
     ICM C08F0212-08
         C08F0220-26; C08F0290-06; C08F0285-00; C08L0067-06; C08L0025-08;
          C08L0053-02
CC
     37-6 (Plastics Manufacture and Processing)
     Section cross-reference(s): 38
     112356-77-1P 115115-55-4P 176779-38-7P 255829-08-4P
ΙT
                    342427-71-8P 342427-72-9P 342428-40-4P
     342420-64-8P
     342428-42-6P
     RL: IMF (Industrial manufacture); MOA (Modifier or additive use); PREP
     (Preparation); USES (Uses)
        (compatibilizing agent for radical-copolymerizable unsatd. resin
        composition, molding material, and molded article)
ΙT
     115115-55-4P 255829-08-4P 342428-40-4P
     RL: IMF (Industrial manufacture); MOA (Modifier or additive use); PREP
     (Preparation); USES (Uses)
        (compatibilizing agent for radical-copolymerizable unsatd. resin
        composition, molding material, and molded article)
RN
     115115-55-4 HCAPLUS
CN
     Poly(oxy-1,2-ethanediyl), \alpha-(2-methyl-1-oxo-2-propenyl)-\omega-
```

methoxy-, polymer with ethenylbenzene, graft (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$H_2C$$
 O H_2C H_2C

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 255829-08-4 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with ethenylbenzene and $\alpha\text{-}(2\text{-methyl-1-oxo-2-propenyl})-\omega\text{-methoxypoly}(\text{oxy-1,2-ethanediyl}), graft (9CI) (CA INDEX NAME)$

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

CM 2

CRN 100-42-5

CMF C8 H8

 $H_2C = CH - Ph$

CM 3

CRN 80-62-6 CMF C5 H8 O2

RN 342428-40-4 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with ethenylbenzene and oxirane, methyl ether, graft (9CI) (CA INDEX NAME)

CM 1

CRN 67-56-1 CMF C H4 O

 $_{
m H3C-OH}$

CM 2

CRN 342428-39-1

CMF (C8 H8 . C5 H8 O2 . C2 H4 O) x

CCI PMS

CM 3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

CM 4

CRN 80-62-6 CMF C5 H8 O2

CM 5

CRN 75-21-8 CMF C2 H4 O

 $^{\circ}$

L110 ANSWER 19 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN AN 2000:881248 HCAPLUS

```
DN
    134:57982
    Binding agents modified by nanoparticles for coating agents and use of the
ΤI
ΙN
    Ducoffre, Volker; Flosbach, Carmen; Tannert, Klaus; Weidenhammer, Petra
PA
    E. I. Du Pont de Nemours & Co., USA
    PCT Int. Appl., 20 pp.
    CODEN: PIXXD2
DT
    Patent
LA
    German
FAN.CNT 1
    PATENT NO.
                        KIND
                               DATE
                                           APPLICATION NO.
                                                                  DATE
    -----
                        ----
                                           ______
                                                                  _____
PΙ
    WO 2000075244
                               20001214
                         A1
                                           WO 2000-EP4695
                                                                  20000524 <--
        W: AU, BR, CN, JP, MX, PL, US, ZA
        RW: AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL,
             PT, SE
    EP 1187885
                         Α1
                                20020320
                                           EP 2000-936787
                                                                  20000524 <--
    EP 1187885
                         В1
                                20021113
            AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
             IE, FI
    AT 227760
                         Т
                                20021115
                                           AT 2000-936787
                                                                  20000524 <--
    JP 2003501543
                                           JP 2001-502518
                         T
                                20030114
                                                                  20000524 <--
    ES 2182805
                         Т3
                                           ES 2000-936787
                               20030316
                                                                  20000524 <--
    US 6649672
                                           US 2002-9382
                         В1
                               20031118
                                                                  20020320 <--
PRAI DE 1999-19925331
                               19990602
                         Α
                                         <--
    WO 2000-EP4695
                         W
                               20000524
                                         <--
AΒ
    Compatibility in nanoparticle-containing coatings is improved by using binders
    obtained by reacting ≥1 epoxy binders with carboxy-functional
    nanoparticles.
IC
    ICM C09D0007-12
    42-5 (Coatings, Inks, and Related Products)
CC
IT
    313355-24-7P
    RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical or
    engineered material use); PREP (Preparation); USES (Uses)
        (crosslinked binders; epoxy binders modified by nanoparticles for
        coatings)
IT
    313257-21-5DP, 1,4-Butanediol monoacrylate-glycidyl methacrylate-isobutyl
    acrylate-styrene copolymer, reaction products with carboxy-functional
    nanoparticles based on silicon-oxygen networks 313257-25-9DP,
    1,4-Butanediol monoacrylate-hydroxypropyl methacrylate-isobutyl
    acrylate-styrene copolymer, reaction products with carboxy-functional
    nanoparticles based on silicon-oxygen networks
    RL: IMF (Industrial manufacture); PEP (Physical, engineering or chemical
    process); PREP (Preparation); PROC (Process)
        (epoxy binders modified by nanoparticles for coatings)
IT
    313355-24-7P
    RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical or
    engineered material use); PREP (Preparation); USES (Uses)
        (crosslinked binders; epoxy binders modified by nanoparticles for
        coatings)
    313355-24-7 HCAPLUS
RN
CN
    2-Propenoic acid, 2-methyl-, monoester with 1,2-propanediol, polymer with
    Cylink 2000, ethenylbenzene, 4-hydroxybutyl 2-propenoate and
    2-methylpropyl 2-propenoate (9CI) (CA INDEX NAME)
    CM
    CRN
         313355-22-5
    CMF
         Unspecified
    CCI
         MAN
```

*** STRUCTURE DIAGRAM IS NOT AVAILABLE ***

CM 2

CRN 2478-10-6 CMF C7 H12 O3

$$^{\circ}_{||}$$
 HO- (CH₂)₄-O-C-CH=CH=CH₂

CM 3

CRN 106-63-8 CMF C7 H12 O2

CM 4

CRN 100-42-5 CMF C8 H8

$$H_2C = CH - Ph$$

CM 5

CRN 27813-02-1 CMF C7 H12 O3 CCI IDS

CM 6

CRN 79-41-4 CMF C4 H6 O2

$$\begin{array}{c} \text{CH}_2\\ \parallel\\ \text{Me-C-CO}_2\text{H} \end{array}$$

CM 7

CRN 57-55-6 CMF C3 H8 O2

RN 313257-25-9 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, monoester with 1,2-propanediol, polymer with ethenylbenzene, 4-hydroxybutyl 2-propenoate and 2-methylpropyl 2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 2478-10-6 CMF C7 H12 O3

CM 2

CRN 106-63-8 CMF C7 H12 O2

CM 3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

CM 4

CRN 27813-02-1 CMF C7 H12 O3

CCI IDS

CM 5

CRN 79-41-4

CMF C4 H6 O2

```
^{\mathrm{CH_2}}_{||} Me^{-\mathrm{C-CO_2H}}
```

CM 6

CRN 57-55-6 CMF C3 H8 O2

ОН | Н3С-СН-СН2-ОН

RETABLE

Referenced Autho: (RAU)	(RPY)	VOL PG (RVL) (RP	G) (RWK)	Work Referenced File
Nippon Carbide Kogyo Ppg Industries Inc			JP 08199090	A HCAPLUS

L110 ANSWER 20 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

AN 2000:68225 HCAPLUS

DN 132:109537

TI Aqueous pigmented ink jet inks for printing on hydrophobic substrates

IN Pearlstine, Kathryn Amy; Grezzo, Page Loretta Ann

PA E. I. Du Pont de Nemours & Co., USA

SO Eur. Pat. Appl., 16 pp.

CODEN: EPXXDW

DT Patent

LA English

FAN.CNT 1

221111	PAT	TENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI		974626 974626	A1 B1	20000126 20040519	EP 1999-110475	19990531 <
			H, DE, DK, T, LV, FI,		GB, GR, IT, LI, LU, NL,	SE, MC, PT,
	US	6087416	A .	20000711	US 1998-120922	19980722 <
	CN	1242399	Α	20000126	CN 1999-110527	19990722 <
		2000044858	Α	20000215	JP 1999-208006	19990722 <
PRAI	US	1998-120922	Α	19980722	<	

An ink jet ink composition suitable for use in printing directly to hydrophobic substrates comprises: (a) an aqueous vehicle containing at least water and a water-miscible solvent selected from the group consisting of glycols and glycol ethers, wherein water constitutes no more than 80% by weight based on the total weight of the vehicle; (b) an insol. colorant; (c) a polymeric dispersant; and (d) a surfactant selected from the group consisting of silicon surfactants and fluorinated surfactants. The ink optionally contains a graft copolymer binder having a hydrophobic backbone and non-ionic, hydrophilic side chains which is soluble in the aqueous vehicle but insol. in water. An ink contained a deprotected benzyl methacrylate-trimethylsilyl methacrylate block copolymer dispersant, diethylene glycol, Dowanol PnP, Byk-019, Silwet L7602, a binder, and

hexylene glycol.

IC ICM C09D0011-00

CC 42-12 (Coatings, Inks, and Related Products)

IT 255829-08-4P

RL: IMF (Industrial manufacture); POF (Polymer in formulation); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (binder; aqueous pigmented ink jet inks for printing on hydrophobic substrates)

IT 255829-08-4P

RL: IMF (Industrial manufacture); POF (Polymer in formulation); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (binder; aqueous pigmented ink jet inks for printing on hydrophobic substrates)

RN 255829-08-4 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with ethenylbenzene and α -(2-methyl-1-oxo-2-propenyl)- ω -methoxypoly(oxy-1,2-ethanediyl), graft (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0 CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$H_2C$$
 O H_2C O H_2CH_2 O H_2CH_2 OME

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

CM 3

CRN 80-62-6 CMF C5 H8 O2

RETABLE

Referenced Author (RAU)	Year	(RPG)	Referenced Work (RWK)	Referenced File
Du Pont	1992		DE 4218734 A	HCAPLUS
Seiko Epson Corp	1994		EP 0586101 A	HCAPLUS
Seiko Epson Corp	1994		EP 0606490 A	HCAPLUS

```
L110 ANSWER 21 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
ΑN
     2000:68210 HCAPLUS
     132:108520
DN
ΤI
    Water-insoluble nonionic graft copolymers
     Grezzo, Page Loretta Amn; Pearlstine, Kathryn Amy; Waifong, Anton L.
IN
PΑ
     E. I. Du Pont de Nemours & Co., USA
SO
     Eur. Pat. Appl., 10 pp.
     CODEN: EPXXDW
DT
     Patent
LA
    English
FAN.CNT 1
     PATENT NO.
                       KIND DATE
                                          APPLICATION NO.
                                                                  DATE
     _____
                       ----
                               -----
                                           -----
    EP 974607
                        A1 20000126
B1 20040929
PΙ
                                         EP 1999-110476
                                                                 19990531 <--
    EP 974607
         R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
             IE, SI, LT, LV, FI, RO
     US 7008992
                                20060307
                         В1
                                           US 1998-120608
                                                                  19980722 <--
     CN 1242378
                                                                  19990722 <--
                         Α
                                20000126
                                           CN 1999-110526
                                           JP 1999-208005
     JP 2000072834
                         Α
                                20000307
                                                                  19990722 <--
PRAI US 1998-120608
                        Α
                               19980722 <--
     A nonionic graft copolymer has a hydrophobic backbone and nonionic,
     hydrophilic side chains having a mol. weight of at least 500, preferably
     100-2000 is substantially insol. in water, but soluble in an aqueous vehicle,
and
     is particularly suited for use in aqueous coating compns. in which water
     comprises no more than 80% by weight of the vehicle for the composition A
     copolymer was prepared from Bisomer S20W, Me methacrylate, and styrene.
     ICM C08F0290-06
IC
     ICS C08F0290-04; C09D0151-00
     35-8 (Chemistry of Synthetic High Polymers)
CC
     Section cross-reference(s): 42
IT
     111740-55-7P 255722-59-9P 255829-08-4P
     RL: IMF (Industrial manufacture); POF (Polymer in formulation); TEM
     (Technical or engineered material use); PREP (Preparation); USES (Uses)
        (water-insol. nonionic graft copolymers)
IT
     255829-08-4P
     RL: IMF (Industrial manufacture); POF (Polymer in formulation); TEM
     (Technical or engineered material use); PREP (Preparation); USES (Uses)
        (water-insol. nonionic graft copolymers)
RN
     255829-08-4 HCAPLUS
CN
     2-Propenoic acid, 2-methyl-, methyl ester, polymer with ethenylbenzene and
    \alpha-(2-methyl-1-oxo-2-propenyl)-\omega-methoxypoly(oxy-1,2-
     ethanediyl), graft (9CI) (CA INDEX NAME)
    CM
          1
         26915-72-0
    CMF
          (C2 H4 O)n C5 H8 O2
    CCI
         PMS
         O-CH<sub>2</sub>-CH<sub>2</sub>-OMe
```

```
CM 2
```

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

CM 3

CRN 80-62-6 CMF C5 H8 O2

RETABLE

Referenced Author (RAU)	(RPY) (R	VL) (RPG)	, , , , , , , , , , , , , , , , , , , ,	Referenced File
Anon	-+ 1992	===+===== 	-+====================================	HCAPLUS
Carrot, G	40	1181	POLYMER BULLETIN	1
Du Pont	1998	İ	EP 0826751 A	HCAPLUS
Du Pont	1998	1	EP 0851014 A	HCAPLUS
Gakkaishi, S	1991 47	650	1	1
Hiroshi, O	1	1	Preparation of copo	11
Hiroyuki, S	1996	1	US 5480953 A	HCAPLUS
Kumar, L	1997	1	WO 9714448 A	HCAPLUS
Roehm Gmbh	11996 I	1	IEP 0691355 A	LHCAPLUS

L110 ANSWER 22 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

AN 1999:21717 HCAPLUS

DN 130:96033

TI Preparation of unsaturated polyoxyalkylene polyols in the presence of vinyl polymerization inhibitors

IN Shen, Jianzhong; McDaniel, Kenneth G.; Hayes, John E.; Holeschovsky, Uli B.; Hinney, Harry R.

PA ARCO Chemical Technology, L.P., USA

SO U.S., 8 pp. CODEN: USXXAM

DT Patent

LA English

FAN. CNT 2

E.WIN.	CNIZ				
	PATENT NO.	KIND DA	TE Z	APPLICATION NO.	DATE
ΡI	US 5854386	A 199	981229	US 1997-918081	19970825 <
	US 6034208	A 200	000307	US 1998-74673	19980508 <
	CA 2294359	A1 199	990304 (CA 1998-2294359	19980824 <
	WO 9910407	A1 199	990304	WO 1998-EP5363	19980824 <
	W: AL, AM, AT,	AU, AZ, BA	A, BB, BG,	BR, BY, CA, CH,	CN, CU, CZ, DE,
	DK, EE, ES,	FI, GB, GI	E, GH, GM,	HR, HU, ID, IL,	IS, JP, KE, KG,
	KP, KR, KZ,	LC, LK, LE	R, LS, LT,	LU, LV, MD, MG,	MK, MN, MW, MX,
	NO, NZ, PL,	PT, RO, RO	U, SD, SE,	SG, SI, SK, SL,	TJ, TM, TR, TT,
	UA, UG, UZ,	VN, YU, ZV	W, AM, AZ,	BY, KG, KZ, MD,	RU, TJ, TM
	RW: GH, GM, KE,	LS, MW, SI	D. SZ. UG.	ZW. AT. BE. CH.	CY. DE. DK. ES.

```
FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE, BF, BJ, CF, CG, CI,
             CM, GA, GN, GW, ML, MR, NE, SN, TD, TG
     AU 9893462
                                 19990316
                                                                     19980824 <--
                          Α
                                             AU 1998-93462
     AU 742676
                          B2
                                 20020110
     ZA 9807644
                          Α
                                 20000403
                                             ZA 1998-7644
                                                                     19980824 <--
     EP 1012203
                          Α1
                                 20000628
                                             EP 1998-946420
                                                                     19980824 <--
     EP 1012203
                          B1
                                 20040721
         R: BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, NL, SE
     BR 9813009
                          Α
                                 20000815
                                             BR 1998-13009
                                                                     19980824 <--
     JP 2001514280
                          T
                                 20010911
                                             JP 2000-507728
                                                                   19980824 <--
     TW 515811
                          В
                                 20030101
                                             TW 1998-87113927
                                                                     19980824 <--
     ES 2224433
                          Т3
                                 20050301
                                             ES 1998-946420
                                                                     19980824 <--
PRAI US 1997-918081
                          A2
                                 19970825
                                           <-<del>-</del>
     US 1998-74673
                          Α
                                 19980508
                                           <--
                                 19980824
     WO 1998-EP5363
                          W
                                          <--
AΒ
     Unique, well defined polyethers containing both hydroxyl-functionality and
     unsatn.-functionality are prepared by oxyalkylating an unsatd. monomer
     having at least one oxyalkylatable hydrogen in the presence of an
     effective amount of a double metal cyanide complex catalyst and in the
     presence of a free radical polymerization inhibitor. The resulting polyethers
     are eminently suitable for such uses as polymer polyol stabilizers or
     stabilizer precursors, and both in situ and ex situ impact modifiers for
     thermoplastics.
IC
     ICM C08G0059-00
INCL 528403000
CC
     35-7 (Chemistry of Synthetic High Polymers)
IT
     111653-36-2P
     RL: IMF (Industrial manufacture); PRP (Properties); PREP (Preparation)
        (preparation of unsatd. polyoxyalkylene polyols in the presence of vinyl
        polymerization inhibitors)
IT
     111653-36-2P
     RL: IMF (Industrial manufacture); PRP (Properties); PREP (Preparation)
        (preparation of unsatd. polyoxyalkylene polyols in the presence of vinyl
        polymerization inhibitors)
RN
     111653-36-2 HCAPLUS
CN
     Poly[oxy(methyl-1,2-ethanediyl)], \alpha-(2-methyl-1-oxo-2-propenyl)-
     \omega-hydroxy-, polymer with ethenylbenzene, graft (9CI) (CA INDEX
     NAME)
     CM
          1
     CRN
          39420-45-6
          (C3 H6 O)n C4 H6 O2
     CMF
     CCI
          IDS, PMS
```

CRN 100-42-5 CMF C8 H8

$H_2C = CH - Ph$

RETABLE

Referenced Author (RAU)	(RPY) (RVL) (F	PG Referenced Work RPG) (RWK)	Referenced File
Anon	1992	IJP 05209052 H	
Herold	11974	US 3829505	HCAPLUS
Kuyper	1984	US 4472560	HCAPLUS
Ramlow	1984	US 4454255	HCAPLUS
Simroth	1993	US 5196476	HCAPLUS

L110 ANSWER 23 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

AN 1998:816477 HCAPLUS

DN 130:117359

TI Ink-jet printing receptor containing dye-receptive polymer and inorganic pigment

IN Mishima, Masayuki

PA Fuji Photo Film Co., Ltd., Japan

SO Jpn. Kokai Tokkyo Koho, 17 pp.

CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

	111.0111 1				
	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	JP 10337948 US 6183851 AI JP 1997-151044	A B1 A	19981222 20010206 19970609	JP 1997-151044 US 1998-92947	19970609 < 19980608 <
GI	(A) OF 1997-131044	. A	199/0609	<	

$$-(CH2-C)- R2$$

$$Lp-N$$

$$R4$$

$$R3$$

- AB The title receptor comprises a support coated with a coating layer containing a dye-receptive polymer I (Rl-4 = H or alkyl which may be branched; L = divalent linking group; p = 0 or 1) and \geq 1 inorg. pigment. The medium shows high ink-drying rate and provides high quality images with good lightfastness.
- IC ICM B41M0005-00 ICS B05D0005-04; B32B0027-00; D21H0019-36; C08F0020-34; C08F0020-60; C08F0026-06
- CC 74-6 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)
 Section cross-reference(s): 38
- TT 7631-86-9, Silica, uses 25232-42-2, 1-Vinylimidazole homopolymer 103437-05-4, 1-Vinylimidazole-1-vinyl-2-pyrrolidone-4-styrenesulfonic acid potassium salt copolymer 115218-48-9, 1-Vinylimidazole-polyethylene glycol methyl ether methacrylate copolymer 219590-19-9,

N-1-Imidazolylethyl acrylamide-polyethylene glycol methyl ether acrylate-sodium methacrylate copolymer

RL: TEM (Technical or engineered material use); USES (Uses)

(ink-jet printing receptor containing dye-receptive polymer and inorg. pigment)

ΙT 115218-48-9, 1-Vinylimidazole-polyethylene glycol methyl ether methacrylate copolymer

RL: TEM (Technical or engineered material use); USES (Uses) (ink-jet printing receptor containing dye-receptive polymer and inorg. pigment)

115218-48-9 HCAPLUS RN

CN 1H-Imidazole, 1-ethenyl-, polymer with α -(2-methyl-1-oxo-2-propenyl)ω-methoxypoly(oxy-1,2-ethanediyl) (9CI) (CA INDEX NAME)

1 CM

CRN 26915-72-0 (C2 H4 O)n C5 H8 O2 CCI PMS

$$H_2C$$
 O H_2C O H_2C O H_2C OMe

CM 2

CRN 1072-63-5 CMF C5 H6 N2

$$N$$
 $CH = CH_2$

L110 ANSWER 24 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

1998:161186 HCAPLUS AN

DN 128:193826

Two-component polyurethane acrylate binders for protective coatings ΤI

Melchiors, Martin; Schwindt, Juergen; Ruttmann, Gerhard; Hovestadt, ΙN Wieland; Probst, Joachim; Pedain, Josef

PΑ

Bayer A.-G., Germany Ger. Offen., 10 pp. SO

CODEN: GWXXBX

DTPatent

LA German

FAN CNT 1

FAN.	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	DE 19634076 EP 825210 EP 825210	A1 A2 A3	19980226 19980225 19980304	DE 1996-19634076 EP 1997-114061	19960823 < 19970814 <

```
EP 825210
                          В1
                                20030827
         R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
             IE, FI
     US 6130285
                          Α
                                20001010
                                            US 1997-911510
                                                                    19970814 <--
     AT 248198
                          T
                                20030915
                                            AT 1997-114061
                                                                    19970814 <--
     ES 2205099
                         Т3
                                            ES 1997-114061
                                20040501
                                                                   19970814 <--
     CA 2213877
                         A1
                             . 19980223
                                            CA 1997-2213877
                                                                   19970819 <--
     JP 10101999
                         Α
                                19980421
                                            JP 1997-239153
                                                                   19970821 <--
     NO 9703869
                          Α
                                19980224
                                            NO 1997-3869
                                                                   19970822 <--
     NO 312971
                          В1
                                20020722
PRAI DE 1996-19634076
                         Α
                                19960823 <--
     The title binders, useful in solvent-free coatings for metals and inorg.
     substrates, comprise polyisocyanates and solvent-free polyols (OH group
     content 3-18%, viscosity 0.2-10 Pa-s at 23°) containing hydroxylated
     polyacrylates, ether-alcs., and, optionally, other alcs. A polyether
     acrylate (I) (OH content 11.1%, viscosity 1.11 Pa-s) was prepared by
     peroxide-initiated polymerization of a mixture of polypropylene glycol (mol.
weight
     437) 50.0, 2-ethylhexyl acrylate 15.9, styrene 6.1, and hydroxyethyl
     methacrylate 8.2 g. A mixture of I 100, HMDI-based biuret polyisocyanate
     (NCO content 23.0%, viscosity 2.75 Pa-s) 122, catalyst 0.1, and additives
     10.4 g (NCO index 100), exposed as a 2-mm film at 50° for 3 days,
     had Shore D hardness 73, blister formation (0 least, 5 most) 0, and
     weathering (same scale) 3.
IC
     ICM C09D0175-04
         C09D0151-08; C08G0018-63; C08G0065-32; C08G0018-10; C08F0283-06;
          B05D0007-16; C23F0011-173
    C08G0018-32; C08G0018-42; C08G0018-60; C08G0018-44; C08G0018-56;
     C08G0018-73; C08G0018-75; C08G0018-76; C08G0018-79
ICI
    C08F0283-06, C08F0220-12, C08F0220-28
CC
     42-10 (Coatings, Inks, and Related Products)
IT
     203793-70-8
                 203793-71-9
                                203793-72-0
                                              203793-73-1 203793-74-2
     203793-75-3
     RL: TEM (Technical or engineered material use); USES (Uses)
        (two-component polyurethane acrylate binders for protective coatings)
IT
     203793-74-2
     RL: TEM (Technical or engineered material use); USES (Uses)
        (two-component polyurethane acrylate binders for protective coatings)
RN
     203793-74-2 HCAPLUS
     2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with butyl
CN
    2-propenoate, ethenylbenzene and \alpha-hydro-\omega-
    hydroxypoly[oxy(methyl-1,2-ethanediyl)] (9CI) (CA INDEX NAME)
    CM
    CRN
         25322-69-4
    CMF
          (C3 H6 O)n H2 O
    CCI
        IDS, PMS
       - (C3H6) - O-
```

CRN 868-77-9 CMF C6 H10 O3

$$^{\rm H_2C}$$
 O $^{\rm H_2C}$ $^{\rm H_2C}$ $^{\rm H_2C}$ $^{\rm H_2-CH_2-OH}$

CRN 141-32-2 CMF C7 H12 O2

CM 4

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

L110 ANSWER 25 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

AN 1998:36706 HCAPLUS

DN 128:102773

TI Synthesis and Characterization of Colloidal Polypyrrole Particles Using Reactive Polymeric Stabilizers

AU Simmons, M. R.; Chaloner, P. A.; Armes, S. P.; Greaves, S. J.; Watts, J.

CS School of Chemistry Physics and Environmental Science, University of Sussex, Falmer / Brighton, BN1 9QJ, UK

SO Langmuir (1998), 14(3), 611-618 CODEN: LANGD5; ISSN: 0743-7463

PB American Chemical Society

DT Journal

LA English

AΒ The use of new "tailor-made" reactive statistical copolymers for the synthesis of sterically stabilized polypyrrole colloids is described. These copolymer stabilizers are readily prepared by free-radical copolymn. of (bi)thiophene-based vinylic monomers with various hydrophilic vinyl monomers such as 2-(dimethylamino)ethyl methacrylate, 2-vinylpyridine, N-vinylpyrrolidone or oligo(ethylene oxide) methacrylate. Monitoring the oxidation of the bithiophene graft sites using visible absorption spectroscopy provided evidence for stabilizer grafting. Relatively high stabilizer efficiencies were obtained and the resulting spherical polypyrrole particles contained 14 to 48% stabilizer by mass and had reasonably narrow size distributions in the 50-100 nm range. Pressed pellet conductivities were as high as 4 S cm-1. XPS studies indicated that the polypyrrole particles were coated with an overlayer of grafted stabilizer, as expected from steric stabilization theory. This route to polypyrrole particles is believed to be completely general and is expected to allow the rational design of steric stabilizers containing a wide range of

```
functional comonomers. This should be useful for the improved design and
     performance of immunodiagnostic assays based on polypyrrole "marker"
     particles.
CC
     37-3 (Plastics Manufacture and Processing)
     Section cross-reference(s): 36, 76
     Conducting polymers
     Electric conductivity
     Particle size
     Sols
    . Stabilizing agents
        (synthesis and characterization of colloidal polypyrrole particles
        using reactive polymeric stabilizers)
     201233-40-1P, 2-(Dimethylamino)ethyl methacrylate-2-vinylthiophene
TΤ
     copolymer
                 201233-41-2P, 2-(Dimethylamino)ethyl methacrylate-3-
     vinylthiophene copolymer 201233-43-4P, 2-(Dimethylamino)ethyl
     methacrylate-5-viny1-2,2'-bithiophene copolymer
                                                      201233-44-5P,
     2-Vinylpyridine-2-vinylthiophene copolymer 201233-45-6P
                                                                201233-46-7P,
     5-Vinyl-2,2'-bithiophene-2-vinylpyridine copolymer 201233-47-8P
     201233-48-9P
                   201233-49-0P, N-Vinylpyrrolidone-3-vinylthiophene
     copolymer
     RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT
     (Reactant or reagent)
        (reactive stabilizer; synthesis and characterization of colloidal
        polypyrrole particles using reactive polymeric stabilizers)
     201233-42-3P, 2-(Dimethylamino)ethyl methacrylate-pyridine-2-
ΙT
     vinylthiophene graft copolymer 201233-50-3P, Pyridine-2-Vinylpyridine-2-
     vinylthiophene graft copolymer 201233-51-4P
                                                   201233-52-5P,
     Pyridine-5-Vinyl-2,2'-bithiophene-2-vinylpyridine graft copolymer
                   201233-54-7P 201233-55-8P 201233-56-9P,
     201233-53-6P
     Pyridine-N-Vinylpyrrolidone-3-vinylthiophene graft copolymer
     201233-57-0P, 2-(Dimethylamino)ethyl methacrylate-pyridine-3-
     vinylthiophene graft copolymer 201233-58-1P, 2-(Dimethylamino)ethyl
     methacrylate-pyridine-5-vinyl-2,2'-bithiophene graft copolymer
     201233-59-2P, 2-(Dimethylamino)ethyl methacrylate-pyridine graft copolymer
     RL: PRP (Properties); SPN (Synthetic preparation); PREP (Preparation)
        (synthesis and characterization of colloidal polypyrrole particles
        using reactive polymeric stabilizers)
     201233-47-8P 201233-48-9P
IT
     RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT
     (Reactant or reagent)
        (reactive stabilizer; synthesis and characterization of colloidal
        polypyrrole particles using reactive polymeric stabilizers)
RN
     201233-47-8 HCAPLUS
CN
     Poly(oxy-1,2-ethanediyl), \alpha-(2-methyl-1-oxo-2-propenyl)-\omega-
     methoxy-, polymer with 3-ethenylthiophene (9CI) (CA INDEX NAME)
     CM
          1
     CRN
          26915-72-0
     CMF
          (C2 H4 O)n C5 H8 O2
     CCI
          PMS
```

CRN 13679-64-6 CMF C6 H6 S

RN 201233-48-9 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, [2,2'-bithiophen]-5-ylmethyl ester, polymer with α -(2-methyl-1-oxo-2-propenyl)- ω -methoxypoly(oxy-1,2-ethanediyl) (9CI) (CA INDEX NAME)

CM 1

CRN 150376-02-6 CMF C13 H12 O2 S2

CM 2

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$H_2C$$
 O H_2C H_2C

IT 201233-53-6P 201233-55-8P

RL: PRP (Properties); SPN (Synthetic preparation); PREP (Preparation) (synthesis and characterization of colloidal polypyrrole particles using reactive polymeric stabilizers)

RN 201233-53-6 HCAPLUS

CN Pyridine, polymer with 3-ethenylthiophene and α -(2-methyl-1-oxo-2-propenyl)- ω -methoxypoly(oxy-1,2-ethanediyl), graft (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$H_2C$$
 O H_2C O H_2C H_2C O H_2C O H_2C H_2C

CRN 13679-64-6 CMF C6 H6 S

CM 3

CRN 110-86-1 CMF C5 H5 N



CN

RN 201233-55-8 HCAPLUS

2-Propenoic acid, 2-methyl-, [2,2'-bithiophen]-5-ylmethyl ester, polymer with α -(2-methyl-1-oxo-2-propenyl)- ω -methoxypoly(oxy-1,2ethanediyl) and pyridine, graft (9CI) (CA INDEX NAME)

CM 1

CRN 150376-02-6 CMF C13 H12 O2 S2

CM2

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$H_2C$$
 O H_2C O H_2C H_2C OMe

CRN 110-86-1 CMF C5 H5 N



RETABLE

Referenced Author (RAU)	Year (RPY)	(RVL)	(RPG)	(RWK)	Referenced File
Anon .	11993			+=====================================	
Arca, E	1994	-	•	Polym Prepr (Am Chem	
Armes, S	11987		288	J Chem Soc, Chem Com	
Armes, S	11989			J Chem Soc, Chem Com	LHCAPLUS
Armes, S	1987			J Colloid Interface	
Armes, S				J Colloid Interface	
Armes, S	11990				HCAPLUS
Armes, S	11987	İ	•	Ph D Thesis, Univers	
Armes, S	1990	131		·	HCAPLUS
Armes, S	11989			Synth Met	1
Armes, S	1990	37			HCAPLUS
Beadle, P	1993	134		= _	HCAPLUS
Beaman, M	1993	271		-	HCAPLUS
Bjorklund, R	1986	1		J Chem Soc, Chem Com	
Bjorklund, R	11987	183		J Chem Soc, Faraday	
Briggs, D	11993	11		Practical Surface An	
Cawdery, N	1988		1189	J Chem Soc, Chem Com	HCAPLUS
Dearmitt, C	11992	150	134	J Colloid Interface	HCAPLUS
Deslandes, Y	11993	19			HCAPLUS
Digar, M	1992		18	J Chem Soc, Chem Com	HCAPLUS
Epron, F	1990			Makromol Chem, Macro	
Finzi, C	11992	25	245	Macromolecules	HCAPLUS
Gospodinova, N	1993			Eur Polym J	HCAPLUS
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Kawaguchi, H				Polymer Materials fo	
Khanna, R					HCAPLUS
Liang, Q					HCAPLUS
Liu, C	•			Polym J	
Liu, J	1991			J Chem Soc, Chem Com	HCAPLUS
Lowe, A	11996				HCAPLUS
Maeda, S	1997				HCAPLUS
Monroy-Soto, V					HCAPLUS
Moss, B	11992	33			HCAPLUS
Napper, D	11983	1120		Polymeric Stabilizat	
Odegard, R	1991	1738	2930	J Electrochem Soc	

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Peters, E
                                           | J Polym Sci, Polym C| HCAPLUS
                                     11379
Pope, M
                        |1996 |7
                                     1436
                                            |Bioconjugate Chem
                                                                 HCAPLUS
Rawi, Z
                                     1215
                        |1992 |68
                                            |Colloids Surf
                                                                   HCAPLUS
Simmons, M
                        |1996 |
                                            |DPhil Thesis, Univer|
Simmons, M
                        |1995 |11
                                     14222
                                            |Langmuir
                                                                   | HCAPLUS
Simmons, M.
                        |1996 |37
                                     12743
                                            | Polymer
                                                                  IHCAPLUS
                        |1995 |72
Stanke, D
                                     189
                                            |Synth Met
                                                                  | HCAPLUS
Stejskal, J
                        |1993 |32
                                   |401
                                            |Polym Int
                                                                  | HCAPLUS
Tarcha, P
                        |1992 |22
                                     1347
                                            |Polymer Latexes:Prep|
Trumbo, D
                        |1988 |26
                                     |3127
                                            | J Polym Sci, Polym C| HCAPLUS
Trumbo, D
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                                            | J Polym Sci, Polym C| HCAPLUS
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                        |1988 |19
                                     1217
                                            |Polym Bull
                                                                  IHCAPLUS
Vincent, B
                        |1990 | -
                                            | J Chem Soc, Chem Com | HCAPLUS
                                     1683
Waltman, R
                        |1984 |131
                                     |1452
                                            | J Electrochem Soc
                                                                 | HCAPLUS
Wei, Y
                        |1993 |
                                     |1160
                                            | J Chem Soc, Chem Com | HCAPLUS
                        |1993 |
Wei, Y
                                     |1160
                                            | J Chem Soc, Chem Com | HCAPLUS
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L110 ANSWER 26 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

1997:632707 HCAPLUS

DN 127:263626

TΙ Process for the preparation of rigid polyurethane foam

Asako, Shinichi; Uchida, Hajime

PΑ Air Products and Chemicals, Inc., USA; Nippon Nyukazai Co. Ltd.

U.S., 6 pp., Cont. of U.S. Ser. No. 310,534, abandoned. SO CODEN: USXXAM

DT Patent

English T.A

FAN.CNT 2

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
ΡI	US 5668187	А	19970916	US 1996-646432	19960507 <
PRAI	JP 1993-73679	A	19930331	<	
	US 1994-310534	В1	19940922	<	

AΒ In a process for the preparation of rigid polyurethane foam from a polyol and a polyisocyanate, it is possible to prepare rigid polyurethane foam by using an aqueous emulsion containing a polymer of ethylenically unsatd. monomers, whereby the amount of chlorofluorocarbon used can be decreased or eliminated. Using the aqueous polymer emulsion also alleviates the deterioration of phys. properties arising from the preparation of rigid polyurethane foam when water is used as a blowing agent.

IC ICM C08G0018-30

INCL 521137000

CC 37-6 (Plastics Manufacture and Processing)

ΙT 25085-19-2P, Acrylic acid-2-ethylhexyl acrylate-styrene copolymer 25085-34-1P, Acrylic acid-styrene copolymer 25586-20-3P, Acrylic acid-butyl acrylate-styrene copolymer 26985-11-5P, Acrylic acid-butyl acrylate-2-hydroxyethyl methacrylate-styrene copolymer 78736-59-1P, Butyl acrylate-polyethylene glycol monomethacrylate copolymer 78736-61-5P, Polyethylene glycol monomethacrylate-styrene 131431-52-2P, Acrylic acid-butyl acrylate-polyethylene glycol monomethacrylate copolymer

RL: IMF (Industrial manufacture); MOA (Modifier or additive use); PREP (Preparation); USES (Uses)

(preparation of rigid polyurethane foams using acrylic polymer emulsions as blowing agents)

78736-61-5P, Polyethylene glycol monomethacrylate-styrene TΤ copolymer

RL: IMF (Industrial manufacture); MOA (Modifier or additive use); PREP (Preparation); USES (Uses)

(preparation of rigid polyurethane foams using acrylic polymer emulsions as

```
blowing agents)
RN
     78736-61-5 HCAPLUS
CN
     Poly(oxy-1,2-ethanediyl), \alpha-(2-methyl-1-oxo-2-propenyl)-\omega-
     hydroxy-, polymer with ethenylbenzene (9CI) (CA INDEX NAME)
     CM
     CRN
          25736-86-1
     CMF
          (C2 H4 O)n C4 H6 O2
     CCI
              O-CH2-CH2
     CM
          2
     CRN 100-42-5
     CMF C8 H8
H_2C = CH - Ph
L110 ANSWER 27 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
AN
     1995:811087 HCAPLUS
DN
     124:9527
     Novel electroactive polymers and block copolymers
ΤI
ΑU
     Khan, I. M.
CS
     Clark Atlanta Univ., GA, USA
SO
     Report (1993), ARO-27141.7-CH-SM; Order No. AD-A276 119, 12 pp.
     From: Gov. Rep. Announce. Index (U. S.) 1994, 94(12), Abstr. No. 433,268
DT
     Report
     English
LA
AΒ
     Synthesis, characterization and properties of microphase separated mixed
     (ionic and electronic) conducting or MIEC block copolymers are reported.
     Polyomega-methoxyocta(oxyethylene)methacrylate-block-4-vinylpyridine,
     abbreviated as PMG8-4VP, and poly-3-methylthiophene-block-omega-
     methoxyocta(oxyethylene)methacrylate, abbreviated as P(3MT-MG8), have been
     synthesized. Both block copolymer series may be appropriately doped to
     generate sep. electronic and ionic conducting microdomains in the overall
     solid matrix. Also, highly ionic conductive solid polymer
     electrolytes have been prepared by blending poly(ethylene oxide),
     poly(2- or 4-vinylpyridine) and LiClO4. All blends were prepared by the
     solution blending process. Optimum blend compns. have been determined such
that
     dimensionally stable elastomeric materials with ionic conductivities around 10\,(-5) S cm-(1) at 25°C are obtained.
CC
     35-4 (Chemistry of Synthetic High Polymers)
     Section cross-reference(s): 36, 39, 76
ST
     ionic electronic conducting solid polymer electrolyte
IT
     Electric conductivity and conduction
        (ionic and electronic conducting solid polymer
        electrolytes)
```

ΙT

Electrolytes

```
(solid, ionic and electronic conducting solid polymer
        electrolytes)
IT
     25014-15-7, Poly(2-vinylpyridine)
                                          25232-41-1, Poly(4-vinylpyridine)
     25322-68-3
     RL: POF (Polymer in formulation); PRP (Properties); USES (Uses)
        (doped; ionic and electronic conducting solid polymer
        electrolytes)
ΙT
                    171274-18-3P
     171274-17-2P
     RL: POF (Polymer in formulation); PRP (Properties); SPN (Synthetic
     preparation); PREP (Preparation); USES (Uses)
        (doped; ionic and electronic conducting solid polymer
        electrolytes)
IT
     171274-17-2P
     RL: POF (Polymer in formulation); PRP (Properties); SPN (Synthetic
     preparation); PREP (Preparation); USES (Uses)
        (doped; ionic and electronic conducting solid polymer
        electrolytes)
RN
     171274-17-2 HCAPLUS
     Pyridine, 4-ethenyl-, polymer with \alpha-(2-methyl-1-oxo-2-propenyl)-
CN
     ω-methoxypoly(oxy-1,2-ethanediyl), block (9CI) (CA INDEX NAME)
          1
     CM
     CRN
          26915-72-0
          (C2 H4 O)n C5 H8 O2
     CCI
          PMS
     CM
          2
     CRN
         100-43-6
     CMF C7 H7 N
  CH=CH2
L110 ANSWER 28 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
     1993:496680 HCAPLUS
AN
DN
     119:96680
ΤI
     Influence of addition of electrolyte and/or increase of
     temperature on the viscoelastic properties of concentrated sterically
     stabilized polystyrene latex dispersions
     Liang, W.; Tadros, T. F.; Luckham, P. F.
ΑU
CS
     Jealott's Hill Res. Stn., ICI Agrochem., Bracknell/Berkshire, RG12 6EY, UK
SO
     Langmuir (1993), 9(8), 2077-83
```

```
CODEN: LANGD5; ISSN: 0743-7463
DT
     Journal
LA
     English
AR
     The viscoelastic properties of aqueous sterically stabilized polystyrene
     dispersions are investigated as a function of Na2SO4 concentration to establish
     the critical flocculation concentration (CFC) at 25°. The critical
flocculation
     temperature (CFT) was also determined from the temperature dependence of the
rheol.
     parameters at fixed Na2SO4 concentration. The results showed that the
dispersion
     became significantly more pseudoplastic at and above the CFC and CFT.
     Both the CFC and CFT were independent of the volume fraction of latex
     dispersions over the range studied (0.35-0.6). Below the CFC and CFT, the
     yield values and moduli showed a slight decrease with increase in
     electrolyte concentration and temperature This was accounted for by the
reduction
     in the adsorbed layer thickness as the solvency of the medium for the
     chains was reduced. However, above the CFC and CFT all rheol. parameters
     showed a sharp increases with increase in both electrolyte
     concentration and temperature A scaling relation between yield value or
storage
     modulus and volume fraction of latex particle was established, which
     demonstrated that a more open structure of flocs may be formed when the
     concentration of electrolyte at a given temperature or the temperature at a
given
     concentration of electrolyte are well above the CFC or CFT. The
     elastic floc model was used to estimate the radius of the flocs above CFC as a
     function of particle volume fraction from the rheol. data. The results
     showed an increase in the floc radius with increase in volume fraction
     (\phi s) at a given Na2SO4 concentration. At any \phi s, the floc radius also
     increases with an increase in Na2SO4 concentration
CC
     36-5 (Physical Properties of Synthetic High Polymers)
ST
     viscoelasticity stabilized polystyrene electrolyte temp; sodium
     sulfate polystyrene dispersion viscoelasticity
IT
     Viscoelasticity
        (of concentrated sterically stabilized polystyrene latex dispersions, effect
        of electrolyte and temperature on, critical flocculation concentration and
        temperature in relation to)
IT
     Flocculation
        (of concentrated sterically stabilized polystyrene latex dispersions, effect
        of electrolyte and temperature on, viscoelastic properties in
        relation to)
IT
     Particle size
        (of flocculated concentrated sterically stabilized polystyrene latex
        dispersions, effect of electrolyte and temperature on)
IT
        (scaling, for viscoelasticity of concentrated sterically stabilized
        polystyrene latex dispersions, electrolyte and temperature effects
IT
     7757-82-6, Sodium sulfate, properties
     RL: PRP (Properties)
        (electrolytes, viscoelastic properties of concentrated sterically
        stabilized polystyrene latex dispersions in presence of, critical
        flocculation concentration and temperature in relation to)
IT
     115115-55-4
     RL: PRP (Properties)
        (latex dispersions, viscoelastic properties of concentrated, effect of
        electrolyte and temperature on, critical flocculation concentration and
```

temperature

in relation to)

IT 115115-55-4

RL: PRP (Properties)

(latex dispersions, viscoelastic properties of concentrated, effect of **electrolyte** and temperature on, critical flocculation concentration and temperature

in relation to)

RN 115115-55-4 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω methoxy-, polymer with ethenylbenzene, graft (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

L110 ANSWER 29 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

AN 1992:521369 HCAPLUS

DN 117:121369

TI Silver halide photographic material

IN Hirabayashi, Kazuhiko; Yoshida, Kazuhiro; Moriya, Tomonobu

PA Konica Co., Japan

SO Eur. Pat. Appl., 47 pp.

CODEN: EPXXDW

DT Patent

LA English

FAN. CNT 1

FAN.CNI I							
	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE		
PI	EP 462758 EP 462758	A2 A3	19911227 19930224	EP 1991-305386	19910614 <		
	R: DE, GB, IT,	NL					
	JP 04051041	A	19920219	JP 1990-158929	19900.618 <		
	US 5153113	Α	19921006	US 1991-714495	19910613 <		
PRAI	JP 1990-158929	A	19900618	<			
os	MARPAT 117:121369						
GI							

AB A Ag halide photog. material having improved antistatic properties and reduced residue color after processing comprises a support, a Ag halide emulsion layer on a surface of the support, an antistatic layer comprising a water-soluble conductive layer, hydrophobic polymer particles, and an epoxy curing agent on the back surface of the support, and a hydrophilic colloid layer adjacent to the antistatic layer and containing a dye represented by the formula I (Q = an aliphatic or aromatic group; R = H or an aliphatic or aromatic

group; M = a cation; L = a methine group; n = an integer of 0-2; p = 1 or 2).

IC ICM G03C0001-83

ICS G03C0001-89

CC 74-2 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)

IT 9081-45-2

RL: USES (Uses)

(with hydrophilic colloid layers containing methine dyes and antistatic layers containing conductive polymers)

IT 9081-45-2

RL: USES (Uses)

(with hydrophilic colloid layers containing methine dyes and antistatic layers containing conductive polymers)

RN 9081-45-2 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω -methoxy-, polymer with ethenylbenzene (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$\begin{array}{c|c} \text{H}_2\text{C} & \text{O} \\ \hline \text{Me-C-C-C} & \text{O-CH}_2\text{--CH}_2 \\ \hline \end{array} \quad \begin{array}{c} \text{OMe} \\ \end{array}$$

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

L110 ANSWER 30 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN AN 1992:436522 HCAPLUS

```
DN
    117:36522
TΤ
    Microencapsulated electrophotographic toner
IN
     Pierce, Zona R.; Sorriero, Louis J.; Tyagi, Dinesh
PΑ
     Eastman Kodak Co., USA
SO
     U.S., 9 pp.
     CODEN: USXXAM
DT
     Patent
     English
LA
FAN.CNT 1
     PATENT NO.
                       KIND
                                DATE
                                          APPLICATION NO.
                                                                   DATE
                         ____
ΡI
     US 5049469
                         Α
                                19910917
                                            US 1989-457674
                                                                   19891227 <--
     US 5162189
                                            US 1991-723590
                        Α
                                19921110
                                                                   19910701 <--
                      A3
PRAI US 1989-457674
                                19891227 <--
     A pressure-sensitive, heat-fusible, microencapsulated electrophotog. toner
     having uniform particle size and phys. characteristics and readily
     transferred from a photoreceptor to a toner image receiver comprises
     particles with an average diameter of 2-20 µm and each having a core and a
     highly uniform enclosing shell, wherein the core comprises a colorant
     0-20, a charge-controlling agent 0.05-5, and a thermoplastic polymer
     (melting temperature 40-150^{\circ}, crystallization deg. 5-80\%) 80-99.95 weight% and
the
     shell comprises colloidal-sized particles of a copolymer comprising an
     addition polymerizable nonionic oleophilic monomer 25-80, an addition
     polymerizable nonionic hydrophilic monomer 5-45, an addition polymerizable
     ionic monomer 1-50, and a crosslinking monomer containing \geq2 addition
     polymerizable groups 8-20 weight%. The copolymer functions as a stabilizer
     controlling the core size of the toner.
IC
     ICM G03G0009-093
INCL 430109000
CC
     74-3 (Radiation Chemistry, Photochemistry, and Photographic and Other
     Reprographic Processes)
     126431-17-2, Ethylene dimethacrylate-2-hydroxyethyl methacrylate-
ΙT
    methacrylic acid-styrene copolymer 142114-23-6, Ethylene
     glycol-2-hydroxyethyl methacrylate-methacrylic acid-styrene copolymer
     142114-24-7, Ethylene glycol-2-hydroxyethyl methacrylate-styrene-4-
     vinylpyridine copolymer
     RL: USES (Uses)
        (outer layers containing, for microencapsulated electrophotog. toners)
ΙT
     142114-23-6, Ethylene glycol-2-hydroxyethyl methacrylate-
     methacrylic acid-styrene copolymer 142114-24-7, Ethylene
     glycol-2-hydroxyethyl methacrylate-styrene-4-vinylpyridine copolymer
     RL: USES (Uses)
        (outer layers containing, for microencapsulated electrophotog. toners)
     142114-23-6 HCAPLUS
RN
CN
     2-Propenoic acid, 2-methyl-, polymer with 1,2-ethanediol, ethenylbenzene
     and 2-hydroxyethyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)
     CM
          1
     CRN 868-77-9
     CMF C6 H10 O3
```

```
CM 2
```

CRN 107-21-1 CMF C2 H6 O2

 $HO-CH_2-CH_2-OH$

CM 3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

CM 4

CRN 79-41-4 CMF C4 H6 O2

 $\begin{array}{c} \text{CH}_2 \\ || \\ \text{Me-C-CO}_2 \text{H} \end{array}$

RN 142114-24-7 HCAPLUS

CN 2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with 1,2-ethanediol, ethenylbenzene and 4-ethenylpyridine (9CI) (CA INDEX NAME)

CM 1

CRN 868-77-9 CMF C6 H10 O3

CM 2

CRN 107-21-1 CMF C2 H6 O2

 $HO-CH_2-CH_2-OH$

CM 3

CRN 100-43-6 CMF C7 H7 N

CM 4

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

```
L110 ANSWER 31 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
     1992:195868 HCAPLUS
DN
     116:195868
ΤI
     Antistatic laminated plastic films
     Ueda, Eiichi; Takada, Masahito
PΑ
     Konica Co., Japan
     Eur. Pat. Appl., 53 pp.
SO
     CODEN: EPXXDW
DТ
     Patent
LA
     English
FAN.CNT 1
     PATENT NO.
                                             APPLICATION NO.
                          KIND
                                 DATE
                                                                     DATE
                                  -----
                          ----
PΙ
     EP 466088
                          A2
                                  19920115
                                              EP 1991-111385
                                                                      19910709 <--
     EP 466088
                           A3
                                 19920603
         R: DE, GB
                         . А
     JP 04068343
                                 19920304
                                              JP 1990-181852
                                                                      19900710 <--
     US 5209985
                                 19930511
                           Α
                                              US 1991-727062
                                                                      19910708 <--
PRAI JP 1990-181852
                                 19900710 <--
                           Α
     The title films, with good adhesion, comprise base films, layers of
     vinylidene chloride (I) polymers, and surface layers of ionic polymers. A
     biaxially-oriented polyester film was coated with 1.2 \mu m (dry basis)
     0.3:11.1:2:86.6 acrylic acid-Et acrylate-itaconic acid-I copolymer, 1.0 \mu m (dry basis) latex of 1:4 maleic acid-Na 4-vinylbenzenesulfonate
     copolymer (mol. weight 5000) 70, 5:1:10:40:5 acrylic acid-Bu acrylate-Bu
     methacrylate-styrene-vinylamine copolymer 40, and a polyepoxide 12 g/L,
     and a gelatin layer to give a film with adhesion (1 best, 5 worst) after 1 .
     min in H2O at 40°
IC
     ICM B32B0027-08
CC
     38-3 (Plastics Fabrication and Uses)
     Section cross-reference(s): 74
IT
     26589-42-4 31514-57-5 54140-78-2 120543-34-2 133417-84-2
     140715-43-1
                   140715-44-2
     RL: USES (Uses)
        (in antistatic plastic film laminates)
IT
     133417-84-2
     RL: USES (Uses)
```

(in antistatic plastic film laminates)
RN 133417-84-2 HCAPLUS
CN Poly(oxy-1,2-ethanediyl), α-(1-oxo-2-propenyl)-ω-hydroxy-,
polymer with ethenylbenzene (9CI) (CA INDEX NAME)

CM 1

CRN 26403-58-7
CMF (C2 H4 O)n C3 H4 O2
CCI PMS

$$H_2C = CH - C - CH_2 - CH_2 - CH_2 - OH$$

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

L110 ANSWER 32 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

AN 1992:174864 HCAPLUS

DN 116:174864

TI Preparation of microlatex dispersions using oil-in-water microemulsions

AU Larpent, C.; Tadros, T. F.

CS Dep. Chim. Org., Ec. Natl. Super. Chim. Rennes, Rennes, Fr.

SO Colloid and Polymer Science (1991), 269(11), 1171-83 CODEN: CPMSB6; ISSN: 0303-402X

DT Journal

LA English

The preparation of microlatex dispersions from microemulsions of a monomer (styrene, Me methacrylate, or vinyl acetate) is described. The microemulsion is prepared by forming a H2O-in-oil emulsion using a low-HLB surfactant (nonylphenol with 5, 6, or 7 mol ethylene oxide) and then titrating with an aqueous solution of a high-HLB surfactant (nonylphenol with

or 16 mol ethylene oxide). A small amount of anionic surfactant (Na lauryl sulfate, Na dodecyl benzene sulfonate, or dioctyl sulfosuccinate) is also incorporated to enhance the stability of the emulsion and facilitate the inversion to an oil-in-H2O microemulsion. The droplet-size distribution of the resulting microemulsion is determined using photon-correlation spectroscopy. Three different catalysts and 3 different polymerization methods are used: thermally induced polymerization using K2S2O8, azobis-2-Me propamidinium dichloride (I), or AIBN. All these initiators require heating to 60°, i.e. above the stability temperature of the microemulsion. In this case, the microlatexes produced are fairly large (37-100 nm diameter) and have a broad particle-size distribution. The 2nd polymerization procedure is chemical induced using a redox system of H2O2 and ascorbic acid. This produces microlatexes with small sizes (18-24 nm diameter) having a narrow-size distribution. The microlatex size is roughly 2-3 times the size of the microemulsion droplets. This shows that

collision between 2-3 microemulsion droplets results in their coalescence during the polymerization process. The 3rd method of polymerization is based on UV

irradiation in conjunction with K2S2O8, I or AIBN initiators. In this case, the microlatex is also small (30-63 nm) with a narrow particle-size distribution. Microlatex particles are also prepared using a mixture of monomers (styrene plus Me methacrylate) or mixture of monomers and methoxy (polyethylene glycol) methacrylate macromonomer. The nonionic latexes are very stable, giving no flocculation up to 6 mol dm-3 NaCl or CaCl2 and critical flocculation concentration (CFC) of 0.6 mol dm-3 for Na2SO4 or MgSO4. Charged latexes are less stable than the nonionic ones. The critical flocculation temps. (CFT) of all latexes are determined as a function of electrolyte concentration With the nonionic latexes, CFC is higher than the θ -temperature for poly(ethylene oxide) at the given electrolyte concentration, indicating enhanced steric stabilization as a result of the dense packing of the chains and hence an elastic contribution to the steric interaction. This is not the case with the charged latex, which shows CFT values lower than the θ -temperature. The lattices containing methoxy poly(ethylene glycol) methacrylate are also less stable towards electrolyte.

CC 35-4 (Chemistry of Synthetic High Polymers)

IT 9003-20-7P, Poly(vinyl acetate) 9003-53-6P, Polystyrene 9011-14-7P, PMMA 9057-52-7P 25034-86-0P, Methyl methacrylate-styrene copolymer 37247-21-5P

RL: SPN (Synthetic preparation); PREP (Preparation)
(microlatexes, preparation and droplet size and stability of)

IT 37247-21-5P

RL: SPN (Synthetic preparation); PREP (Preparation) (microlatexes, preparation and droplet size and stability of)

RN 37247-21-5 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(1-oxo-2-propenyl)- ω -methoxy-, polymer with ethenylbenzene (9CI) (CA INDEX NAME)

CM 1

CRN 32171-39-4 CMF (C2 H4 O)p C4

CMF (C2 H4 O)n C4 H6 O2

CCI PMS

$$H_2C = CH - C - CH_2 - CH_2 - CH_2 - OME$$

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

L110 ANSWER 33 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN AN 1992:162459 HCAPLUS DN 116:162459

```
Silver halide photographic material having an antistatic backing layer
TΙ
     containing an electroconductive polymer and a hydrophilic polymer
ΙN
     Yoshida, Kazuhiro
     Konica Co., Japan
PΑ
     Jpn. Kokai Tokkyo Koho, 16 pp.
SO
     CODEN: JKXXAF
DT
     Patent
LA
     Japanese
FAN.CNT 1
     PATENT NO.
                         KIND
                                 DATE
                                             APPLICATION NO.
                                                                     DATE
                         ____
                                 _____
                                             _____
     JP 03241340
PΤ
                                 19911028
                                            JP 1990-38977
                                                                     19900220 <--
PRAI JP 1990-38977
                                 19900220 <--
     The photog. material has a layer containing (a) a water-soluble elec.
conductive
     polymer, (b) solid particles of hydrophilic polymer and (c) an epoxy-type
     hardening agent, and an adjacent hydrophilic colloid layer hardened by a
     triazine-type hardening agent. It has excellent anti-static property
     without inducing pinhole defects on developed images.
IC
     ICM G03C0001-89
     ICS G03C0001-30
CC
     74-2 (Radiation Chemistry, Photochemistry, and Photographic and Other
     Reprographic Processes)
IT
     Electric conductors, polymeric
        (antistatic photog. film containing)
ΙT
     9081-45-2
               58048-89-8 66167-58-6
     RL: USES (Uses)
        (hydrophobic, antistatic photog. film containing)
ΙT
     9081-45-2
     RL: USES (Uses)
        (hydrophobic, antistatic photog. film containing)
RN
     9081-45-2 HCAPLUS
CN
     Poly(oxy-1,2-ethanediyl), \alpha-(2-methyl-1-oxo-2-propenyl)-\omega-
     methoxy-, polymer with ethenylbenzene (9CI) (CA INDEX NAME)
     CM
     CRN
          26915-72-0
     CMF
          (C2 H4 O)n C5 H8 O2
     CCI
         PMS
 H<sub>2</sub>C
              o-сн<sub>2</sub>-сн<sub>2</sub>-
```

$$\begin{array}{c|c}
\text{H2C O} \\
\text{Me-C-C}
\end{array}$$

$$\begin{array}{c|c}
\text{O-CH}_2 - \text{CH}_2
\end{array}$$

$$\begin{array}{c|c}
\text{OMe}$$

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

L110 ANSWER 34 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

```
ΑN
     1992:107447 HCAPLUS
DN
     116:107447
TΙ
     Composite polymer microsphere manufacture
ΙN
     Noda, Ippei; Abe, Masanobu; Sugiura, Fumitoshi
     Takemoto Oil and Fat Co., Ltd., Japan
PΑ
SO
     Jpn. Kokai Tokkyo Koho, 15 pp.
     CODEN: JKXXAF
DT
     Patent
LA
     Japanese
FAN.CNT 3
     PATENT NO.
                                 DATE
                          KIND
                                             APPLICATION NO.
                                                                     DATE
     -----
                          ____
                                 -----
                                             -----
                                                                     _____
                         Α
PΤ
     JP 03244637
                                 19911031
                                             JP 1990-42130
                                                                     19900222 <--
     JP 2942298
                         B2
                                 19990830
     US 5296569
                         Α
                                 19940322
                                             US 1993-46393
                                                                     19930412 <--
PRAI JP 1990-42130
                         Α
                                 19900222
                                           <--
     JP 1990-81986
                         Α
                                 19900329
                                           <--
     US 1991-655109
                         B2
                                 19910214 <--
     Particles with average diameter (D) 0.05-30~\mu m, standard deviation (Ds)
1.0 - 2.5,
     and aspect ratio (R) 1.0-1.2, useful as lubrication modifiers for
     polyester moldings, mold release agents, or antiblocking agents for
     plastic films, are mixts. of 3-70% vinyl polymers with no SiOH-reactive
     groups and 30-90% siloxanes bearing no radically-polymerizable groups.
     Thus, stirring a 2-phase aqueous solution of Si(OEt)4,
     octamethyldichlorotetrasiloxane, MeSi(OMe)3, and styrene for 5 h gave
     particles, heating of which in H2O at 70^\circ with K2S2O8 for 4 h gave spheres with Da 1.1 \mum, Ds 1.42, R 1.02, and siloxane content 86.3%.
IC
     ICM C08J0003-12
     ICS C08L0043-04; C08L0083-04
     37-3 (Plastics Manufacture and Processing)
CC
     9003-53-6P, Polystyrene 9003-70-7P, Divinylbenzene-styrene copolymer
IT
     9011-14-7P, PMMA 78736-61-5P, Polyoxyethylene
     monomethacrylate-styrene copolymer
     RL: PREP (Preparation)
        (siloxane blends, microspheres, manufacture of)
IT
     78736-61-5P, Polyoxyethylene monomethacrylate-styrene copolymer
     RL: PREP (Preparation)
        (siloxane blends, microspheres, manufacture of)
RN
     78736-61-5 HCAPLUS
CN
     Poly(oxy-1,2-ethanediyl), \alpha-(2-methyl-1-oxo-2-propenyl)-\omega-
     hydroxy-, polymer with ethenylbenzene (9CI) (CA INDEX NAME)
     CM
     CRN
          25736-86-1
     CMF
          (C2 H4 O)n C4 H6 O2
     CCI
          PMS
```

$$H_2C$$
 O H_2C O H_2C OH H_2C OH H_2C OH H_2C

· CM 2

CRN 100-42-5

CMF C8 H8

```
H_2C = CH - Ph
```

```
L110 ANSWER 35 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
    1991:418499 HCAPLUS
AN
DN
    115:18499
TΙ
    Antistatic layer
    Tachibana, Noriki; Saito, Yoichi; Yamazaki, Toshiaki
PA
    Konica Co., Japan
SO
    Eur. Pat. Appl., 28 pp.
    CODEN: EPXXDW
DT
    Patent
    English
FAN.CNT 1
                       KIND DATE
    PATENT NO.
                                          APPLICATION NO.
                                                                 DATE
                        ____
                              -----
                                          -----
                                                                 _____
PΙ
    EP 398223
                        A2
                               19901122
                                         EP 1990-109055
                                                                 19900514 <--
    EP 398223
                        A3 19910327
        R: DE, GB, NL
     JP 03067248
                        Α
                              19910322
                                          JP 1990-47018
                                                                 19900227 <--
    JP 03067249
                                          JP 1990-118276
                         Α
                               19910322
                                                                 19900508 <--
    US 5084339
                                         US 1990-521591
                         A
                               19920128
                                                                 19900510 <--
PRAI JP 1989-122564
                              19890516 <--
                        Α
    A plastic film, e.g., photog. film, with an antistatic layer is claimed
    where the antistatic layer is comprised of a H2O-soluble electroconductive
    polymer, hydrophobic polymer particles, and a curing agent, and the
    hydrophobic polymer has a polyalkylene oxide chain. The film has
    excellent antistatic property. Thus, an antistatic layer was formed with
     a hydrophobic polymer from styrene-decaoxyethylene acrylate copolymer.
IC
     ICM G03C0001-85
    74-2 (Radiation Chemistry, Photochemistry, and Photographic and Other
CC
     Reprographic Processes)
IT
     120543-34-2 130341-38-7 133417-84-2
                                           134119-91-8
     134247-85-1 134247-86-2 134247-87-3
                                           134247-88-4
     134247-89-5
                134289-46-6
    RL: USES (Uses)
        (antistatic layer containing, for photog. films)
ΙT
    133417-84-2 134247-85-1 134247-86-2
    RL: USES (Uses)
        (antistatic layer containing, for photog. films)
RN
    133417-84-2 HCAPLUS
CN
    Poly(oxy-1,2-ethanediyl), \alpha-(1-oxo-2-propenyl)-\omega-hydroxy-,
    polymer with ethenylbenzene (9CI) (CA INDEX NAME)
    CM
         1
    CRN 26403-58-7
     CMF
          (C2 H4 O)n C3 H4 O2
    CCI
        PMS
```

 $H_2C = CH - C - CH_2 - CH_2 - CH_2 - OH$

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

RN 134247-85-1 HCAPLUS

CN 2-Propenoic acid, polymer with butyl 2-propenoate, ethenylbenzene, $\alpha-hydro-\omega-hydroxypoly(oxy-1,2-ethanediyl)$ and $\alpha-hydro-\omega-hydroxypoly[oxy(2-hydroxy-1,3-propanediyl)] (9CI) (CA INDEX NAME)$

CM 1

CRN 26403-55-4

CMF (C3 H6 O2)n H2 O

CCI PMS

HO
$$CH_2$$
 CH_2 CH_2 CH_2 OH_2 OH_2 OH_3 OH_4 CM 2

CRN 25322-68-3

CMF (C2 H4 O)n H2 O

CCI PMS

CM 3

CRN 141-32-2 CMF C7 H12 O2

CM 4

CRN 100-42-5 CMF C8 H8 $H_2C = CH - Ph$

CM 5

CRN 79-10-7 CMF C3 H4 O2

RN 134247-86-2 HCAPLUS

CN 2-Propenoic acid, butyl ester, polymer with ethenylbenzene and $\alpha\text{-}(1\text{-}oxo\text{-}2\text{-}propenyl)\text{-}\omega\text{-}hydroxypoly(oxy-1,2-ethanediyl)}$ (9CI) (CA INDEX NAME)

CM 1

CRN 26403-58-7

CMF (C2 H4 O)n C3 H4 O2

CCI PMS

$$H_2C = CH - C - CH_2 - CH_2 - CH_2 - OH_2 $

CM 2

CRN 141-32-2 CMF C7 H12 O2

CM 3

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

L110 ANSWER 36 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN AN 1989:439977 HCAPLUS

```
DN
     111:39977
     ABA triblock comb copolymers with oligo(oxyethylene) side chains as matrix
ΤI
     for ion transport
ΑU
     Khan, Ishrat M.; Fish, Daryle; Delaviz, Yadollah; Smid, Johannes
     Coll. Environ. Sci. Forestry, State Univ. New York, Syracuse, NY, 13210,
CS
SO
     Makromolekulare Chemie (1989), 190(5), 1069-78
     CODEN: MACEAK; ISSN: 0025-116X
DT
     Journal
LA
     English
     ABA triblock copolymers consisting of two terminal blocks (A) of comblike
AB
     polymethacrylate with oligo(oxyethylene) (average d.p. 8) side chains and a
     middle block B of polystyrene were synthesized by anionic polymerization The
     polymers were then solution cast from THF solns. of LiClO4 and the
     homogeneous, solvent-free polymer electrolyte systems tested for
     their thermal characteristics (DSC) and conductivity The inclusion of a
     polystyrene block in the comblike polymethacrylate electrolyte
     vastly improved their film-forming and mech. properties, but also lowered
     the conductivity Addition of MeO(CH2CH2O)4Me enhanced the ion conduction which
     could reach values of 10-4 \Omega-1.cm-1 at 70^{\circ}, depending on salt
     and styrene content.
CC
     35-4 (Chemistry of Synthetic High Polymers)
     Section cross-reference(s): 36
    112119-04-7P 697284-07-4P
     RL: SPN (Synthetic preparation); PREP (Preparation)
        (preparation and characterization of)
IT
     7439-93-2DP, Lithium, complexes with \alpha\text{-methacryloyl-}\omega\text{-}
     methoxypolyethylene glycol-styrene block graft copolymers
     112119-04-7DP, lithium complexes 121653-08-5DP, Me ether,
     lithium complexes 697284-07-4DP, lithium complexes
     RL: PRP (Properties); SPN (Synthetic preparation); PREP (Preparation)
        (preparation and elec. conductivity of)
IT
     112119-04-7P 697284-07-4P
     RL: SPN (Synthetic preparation); PREP (Preparation)
        (preparation and characterization of)
     112119-04-7 HCAPLUS
RN
CN
     Poly(oxy-1,2-ethanediyl), \alpha-(2-methyl-1-oxo-2-propenyl)-\omega-
     methoxy-, polymer with ethenylbenzene, block (9CI) (CA INDEX NAME)
     CM
     CRN
          26915-72-0
          (C2 H4 O)n C5 H8 O2
     CMF
     CCI
          PMS
 H<sub>2</sub>C
```

CRN 100-42-5 CMF C8 H8

```
H_2C = CH - Ph
```

RN 697284-07-4 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω -methoxy-, polymer with ethenylbenzene, triblock (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

IT 112119-04-7DP, lithium complexes 697284-07-4DP, lithium complexes

RL: PRP (Properties); SPN (Synthetic preparation); PREP (Preparation) (preparation and elec. conductivity of)

RN 112119-04-7 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω methoxy-, polymer with ethenylbenzene, block (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$\begin{array}{c|c} \text{H}_2\text{C} & \text{O} \\ \parallel & \parallel \\ \text{Me-C-C} & \text{C-CH}_2\text{--CH}_2 \\ \end{array} \begin{array}{c} \text{OMe} \\ \end{array}$$

CM 2

CRN 100-42-5

CMF C8 H8

```
H_2C = CH - Ph
RN
     697284-07-4 HCAPLUS
CN
     Poly(oxy-1,2-ethanediyl), \alpha-(2-methyl-1-oxo-2-propenyl)-\omega-
     methoxy-, polymer with ethenylbenzene, triblock (9CI) (CA INDEX NAME)
     CM
          1
     CRN
          26915-72-0
     CMF
         (C2 H4 O)n C5 H8 O2
     CCI
         PMS
 H<sub>2</sub>C 0
              о-сн<sub>2</sub>-сн<sub>2</sub>-
     CM
     CRN
         100-42-5
     CMF C8 H8
H_2C = CH - Ph
L110 ANSWER 37 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
     1988:473995 HCAPLUS
DN
     109:73995
TI
     Nonionic polystyrene latexes in aqueous media
ΑU
     Ottewill, Ronald H.; Satgurunathan, Rajasingham; Waite, Frederick A.;
     Westby, Margaret J.
CS
     Sch. Chem., Univ. Bristol, Bristol, BS8 1TS, UK
SO
     British Polymer Journal (1987), 19(5), 435-40
     CODEN: BPOJAB; ISSN: 0007-1641
DT
     Journal
LĄ
     English
     Colloidally stable nonionic polystyrene latexes were prepared in aqueous media,
AΒ
     with a narrow distribution of particle sizes, using a nonylphenol
     polyethylene glycol condensate as the surface-active agent, methoxy
     polyethylene glycol methacrylate as the comonomer-stabilizer and ascorbic
     acid-H2O2 as the initiator system. These latexes were characterized using
     TEM, conductometric titration, and microelectrophoresis. The stability of
     the latexes to the addition of electrolyte was examined and also the
     stability to freeze-thaw conditions. The glass transition temps. of the
     latexes were also determined
CC
     35-4 (Chemistry of Synthetic High Polymers)
     Section cross-reference(s): 36
     9081-45-2P
IT
     RL: SPN (Synthetic preparation); PREP (Preparation)
        (latex, preparation and properties of)
IT
     9081-45-2P
     RL: SPN (Synthetic preparation); PREP (Preparation)
        (latex, preparation and properties of)
```

RN 9081-45-2 HCAPLUS

CN Poly(oxy-1,2-ethanediyl), α -(2-methyl-1-oxo-2-propenyl)- ω -methoxy-, polymer with ethenylbenzene (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

CMF (C2 H4 O)n C5 H8 O2

CCI PMS

CM 2

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

L110 ANSWER 38 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN

AN 1988:446030 HCAPLUS

DN 109:46030

TI Polymer mordants for color photographic elements

IN Shibata, Takeshi; Hirano, Tsumoru

PA Fuji Photo Film Co., Ltd., Japan

SO Ger. Offen., 28 pp.

CODEN: GWXXBX

DT Patent

LA German

FAN. CNT 1

ran.cni i								
		PATENT NO.	KIND	DATE	APPLICATION NO.	DATE		
1	PΙ	DE 3712900	A1	19871029	DE 1987-3712900	19870415 <		
		JP 62244043	Α	19871024	JP 1986-87180	19860417 <		
		JP 06082211	В	19941019				
		JP 62244036	A	19871024	JP 1986-87181	19860417 <		
		JP 06095197	В	19941124				
		US 4774162	Α	19880927	US 1987-39561	19870417 <		
]	PRAI	JP 1986-87180	A	19860417	<			
		JP 1986-87181	Α	19860417	<			
(GΙ							

$$-(CH_2CR^1)$$
 $(Z)_p - N$
 R^2
 R^3
 R^3

AB Polymer mordants for use in color photog. materials contg repeating units of the formula I (R1-R4 = H, alkyl; Z = divalent group; p = 0 or 1) along with repeating units from other ethylenically unsatd. compds. The polymer mordants produce layers that have decreased brittleness and decreased tendency to crack. Thus, a dye-fixing sheet was prepared by coating a polyethylene-laminated paper support with a layer containing a tetraethylene glycol Me ether methacrylate-1-vinyulimidazole copolymer, gelatin, and guanidine picolinate and a layer containing gelatin and a hardening agent. This sheet was then combined with an exposed heat-developable diffusion-transfer color photog. element and processed to produce a stable image that was resistant to crack formation.

IC ICM G03C0001-06

ICS G03C0007-26; G03C0007-18; C08L0039-04

CC 74-2 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)

IT 115218-39-8P 115218-41-2P 115218-42-3P **115218-48-9P**

RL: PREP (Preparation)

(preparation of, as mordant for heat-developable color diffusion-transfer photog. material)

· IT 115218-48-9P

RL: PREP (Preparation)

(preparation of, as mordant for heat-developable color diffusion-transfer photog. material)

RN 115218-48-9 HCAPLUS

CN 1H-Imidazole, 1-ethenyl-, polymer with α -(2-methyl-1-oxo-2-propenyl)- ω -methoxypoly(oxy-1,2-ethanediyl) (9CI) (CA INDEX NAME)

CM 1

CRN 26915-72-0

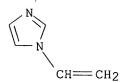
CMF (C2 H4 O)n C5 H8 O2

CCI PMS

$$\begin{array}{c|c} \text{H}_2\text{C} & \text{O} \\ \parallel & \parallel \\ \text{Me-C-C} & \text{O-CH}_2\text{-CH}_2 \\ \hline \end{array} \quad \text{OMe}$$

CM 2

CRN 1072-63-5 CMF C5 H6 N2



L110 ANSWER 39 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN AN 1986:581484 HCAPLUS

```
DN
     105:181484
TΙ
     Toner compositions containing complex ionophoric polymeric materials
IN
     Smith, Thomas W.; Teegarden, David M.; McGrane, Kathleen M.; Luca, David
     J.
PA
     Xerox Corp. , USA
SO
     U.S., 14 pp.
     CODEN: USXXAM
DT
     Patent
LA
     English
FAN.CNT 1
     PATENT NO.
                         KIND
                                DATE
                                            APPLICATION NO.
                                                                   DATE
     -----
                         ____
                                -----
                                            -----
PΙ
     US 4592989
                         Α
                                19860603
                                            US 1985-722975
                                                                   19850412 <--
     JP 61239250
                         Α
                                19861024
                                            JP 1986-77520
                                                                   19860403 <--
     JP 06100845
                         В
                                19941212
     EP 198663
                         A1
                                19861022
                                            EP 1986-302633
                                                                   19860409 <--
     EP 198663
                                19900808
                          B1
         R: BE, FR, GB, IT
     ES 553869
                          A1
                                19871216
                                            ES 1986-553869
                                                                   19860410 <--
     CA 1269560
                                19900529
                                            CA 1986-506279
                          Α1
                                                                   19860410 <--
PRAI US 1985-722975
                                19850412 <--
                          Α
     An electrostatic toner composition comprises resin particles, pigment
     particles, and a complex of a dipolar mol. or salt attached to an
     ionophoric polymer. Thus, styrene-ethylene oxide block copolymer (I) of
     mol. weight 13,200-20,300 was prepared Then, a toner composition was prepared
by melt
     blending 84 weight% STYRON 686 with 6 weight% Regal 330 C black and 10 weight%
of I
     complexes with 15 weight% of KSCN based on oxyethylene-content of I. A pos.
     triboelec. charge of >30 \mu\text{C/g} was achieved with this toner.
IC
     ICM G03G0009-00
     ICS G03G0009-08
INCL 430110000
     74-3 (Radiation Chemistry, Photochemistry, and Photographic and Other
CC
     Reprographic Processes)
IT
     109-99-9DP, derivs., polymers 37247-21-5P
     RL: PREP (Preparation)
        (preparation of, for electrostatic toner composition)
IT
     37247-21-5P
     RL: PREP (Preparation)
        (preparation of, for electrostatic toner composition)
RN
     37247-21-5 HCAPLUS
CN
     Poly(oxy-1,2-ethanediyl), \alpha-(1-oxo-2-propenyl)-\omega-methoxy-,
     polymer with ethenylbenzene (9CI) (CA INDEX NAME)
     CM
          1
     CRN
          32171-39-4
     CMF
          (C2 H4 O)n C4 H6 O2
     CCI
          PMS
```

$$H_2C = CH - C - CH_2 - CH_2 - CH_2 - OMe$$

CRN 100-42-5 CMF C8 H8

CMF C6 H10 O3

 $H_2C = CH - Ph$

```
L110 ANSWER 40 OF 40 HCAPLUS COPYRIGHT 2007 ACS on STN
    1985:549357 HCAPLUS
DN
    103:149357
    Resin compositions containing rare-earth compounds for neutron shielding
TΙ
    Mitsubishi Rayon Co., Ltd., Japan
    Jpn. Kokai Tokkyo Koho, 6 pp.
    CODEN: JKXXAF
DT
    Patent
LA
    Japanese
FAN.CNT 3
    PATENT NO.
                      KIND DATE
                                        APPLICATION NO.
                                                               DATE
                      ----
                                         -----
PΙ
    JP 60099150
                       Α
                            19850603 JP 1984-218744
                                                              19841019 <--
    US 4563494
                       Α
                             19860107
                                         US 1983-548444
                                                              19831103 <--
PRAI US 1983-548444
                       Α
                             19831103 <--
    JP 1982-195800
                              19821108 <--
                       Α
    JP 1982-195801
                       Α
                              19821108 <--
    JP 1982-195802
                       Α
                             19821108 <--
    Transparent compns. having excellent shielding properties for thermal n
AΒ
    comprise transparent thermoplastic and/or thermosetting resins and Gd, Sm,
    and/or Eu compds. Thus, a mixture of Gd nitrate 3, 2-hydroxyethyl
    methacrylate 17, propylene glycol 2, styrene 78, 2,2'-azobis(2,4-
    dimethylvaleronitrile) 0.1, and Na dioctyl sulfosuccinate was poured into
    a mold, which was immersed in hot water at 65° for 4 h and heated
    at 120° for 120 min to give a 3-mm transparent plate with light
    transmittance 91%, thermal n-absorbing cross section 2400 cm2, and
    flexural strength 720 kg/cm2.
    ICM C08L0025-04
    ICS C08F0002-44; G02B0001-04
    71-4 (Nuclear Technology)
    Section cross-reference(s): 38
    9003-53-6 9010-92-8 25034-86-0
IT
                                        26010-51-5 92232-25-2
    98473-90-6 98473-91-7 98473-92-8
    RL: PROC (Process)
       (containing gadolinium, samarium and/or europium compds., transparent, for
       shielding of thermal neutron)
ΙT
    98473-90-6
    RL: PROC (Process)
       (containing gadolinium, samarium and/or europium compds., transparent, for
       shielding of thermal neutron)
RN
    98473-90-6 HCAPLUS
    2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with
CN
    ethenylbenzene and 1,2-propanediol (9CI) (CA INDEX NAME)
    CM
    CRN
         868-77-9
```

CRN 100-42-5 CMF C8 H8

 $H_2C = CH - Ph$

CM 3

CRN 57-55-6 CMF C3 H8 O2